

콜로이드 양자점의 물성 제어 및 소자 응용

Control of Physical Properties and Device Applications of Colloidal Quantum Dots

2026.05.21

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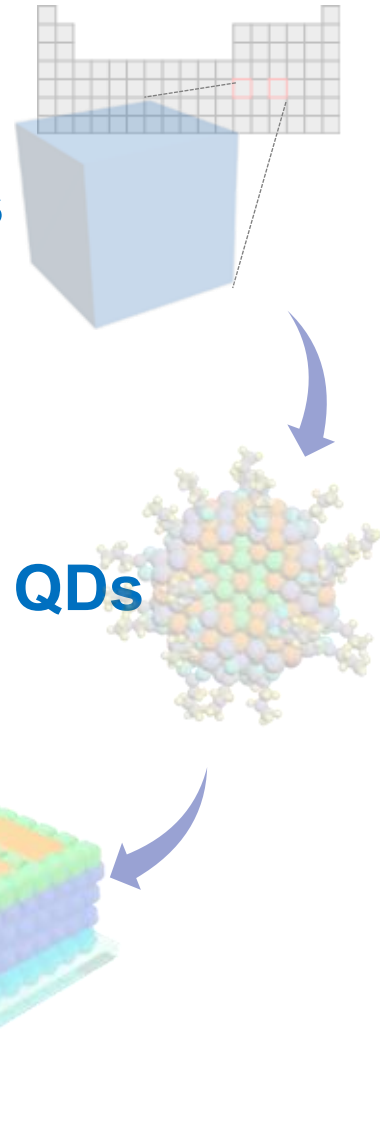
2. Device Applications Using Ionic Crystal QDs

1. Control of Physical Properties by Surface Modification
2. Emerging Applications of CQD Devices

3. Device Applications Using Covalent Crystal QDs

1. Control of Physical Properties by Surface Modification
2. Solar cells using Covalent Crystal QDs

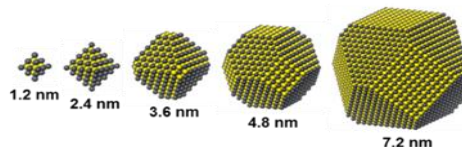
4. Conclusion



What is quantum dot?

콜로이드 양자점 소재 → 태양전지, FET, LED 소자 적용

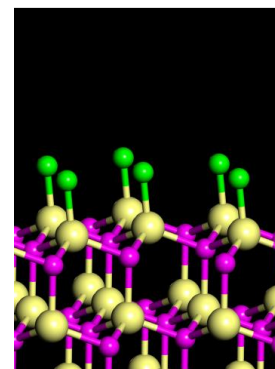
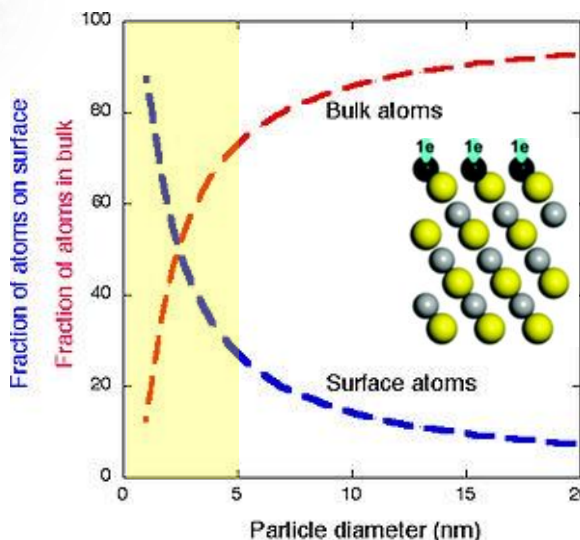
무기 반도체 코어



표면 리간드

기본물성을 정의하는
최소 단위

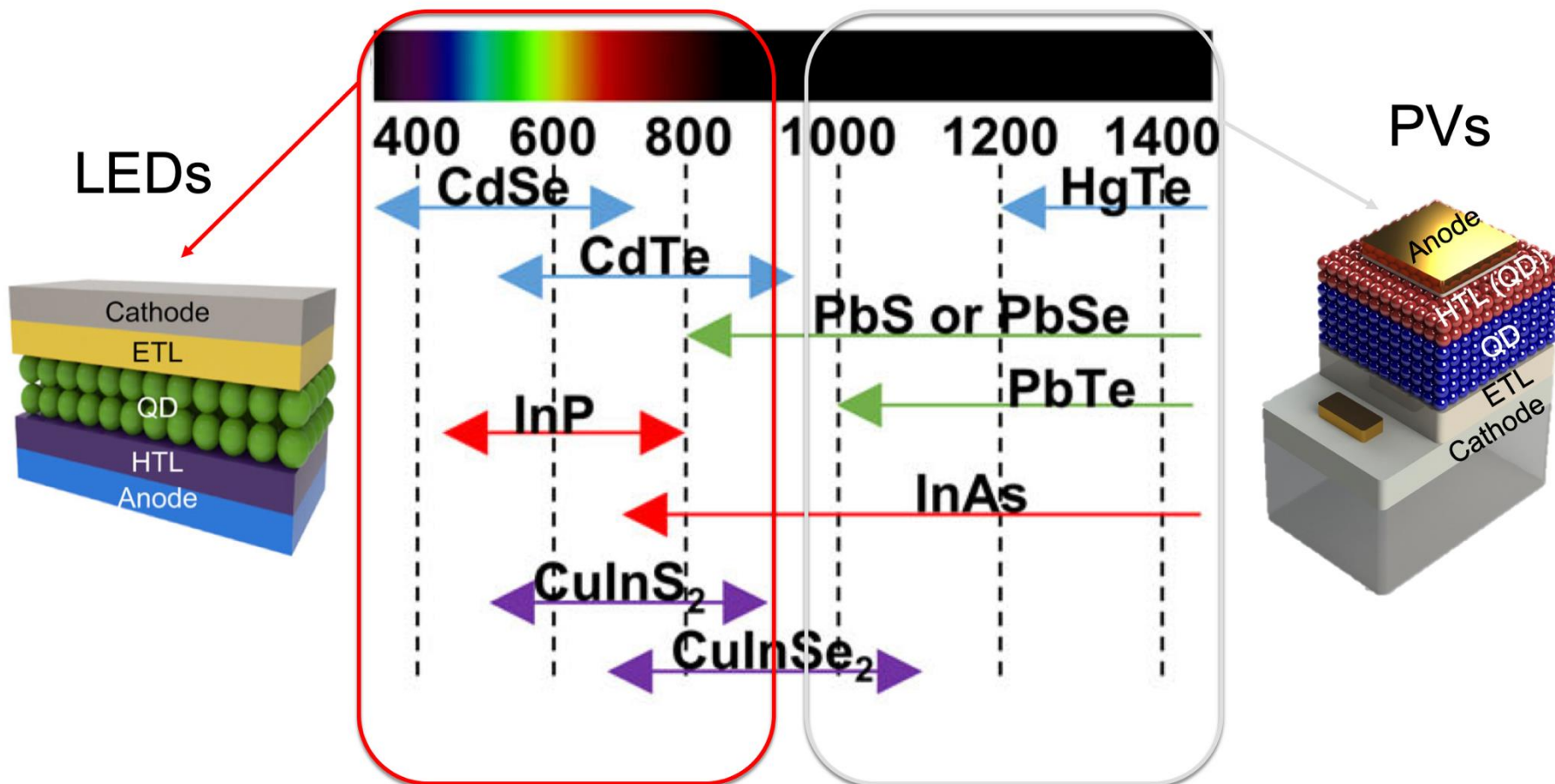
표면상태



- 용액 합성 공정 (저가 공정 가능)
- 표면 기능화를 통한 다양한 물성 제어 가능

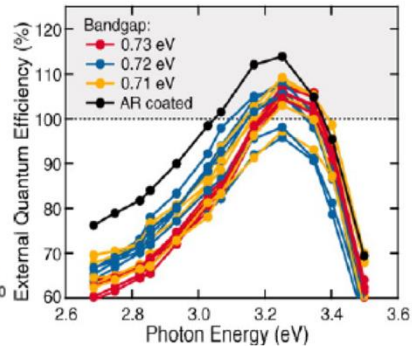
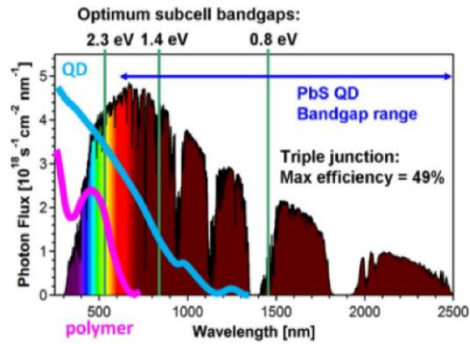
What is quantum dot?

Spectral range of CQDs with various semiconductor materials



Potential for Optoelectronic Applications

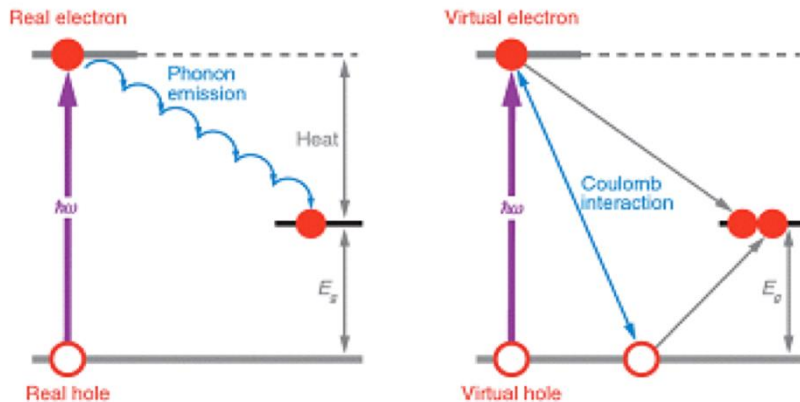
Photovoltaics



Bawendi group webpage

A. J. Nozik, and M. C. Beard, et al.,
Science 334, 1530 (2011)

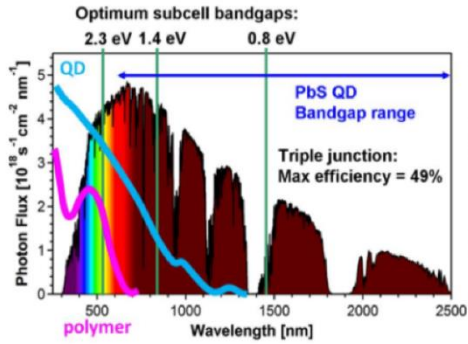
- ✓ Promise efficiency boost *via* minimizing thermal loss (hot carrier utilization)



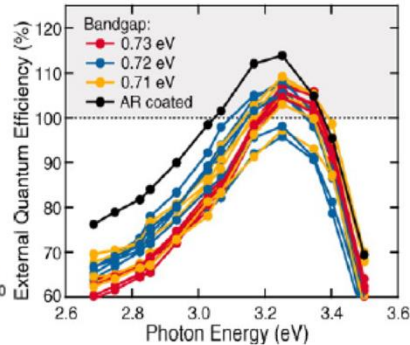
R. D. Schaller, and V. I. Klimov, *Phys. Rev. Lett.*, 92, 186601 (2014)

Potential for Optoelectronic Applications

Photovoltaics

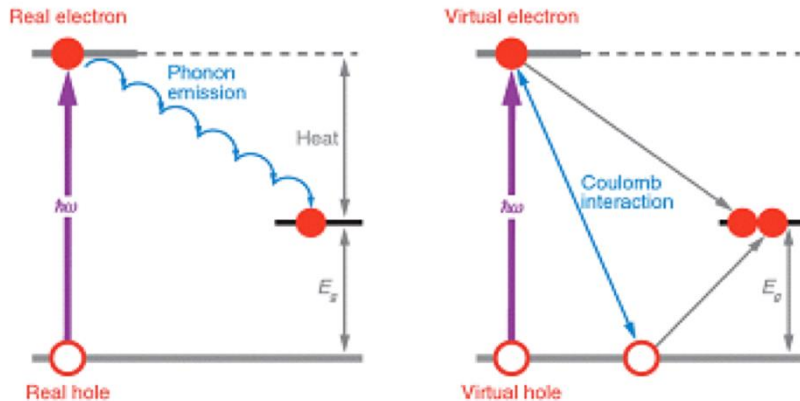


Bawendi group webpage



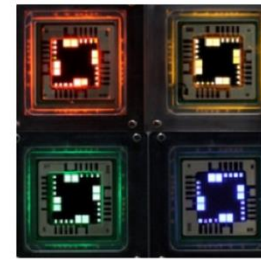
A. J. Nozik, and M. C. Beard, et al.,
Science 334, 1530 (2011)

- ✓ Promise efficiency boost via minimizing thermal loss (hot carrier utilization)

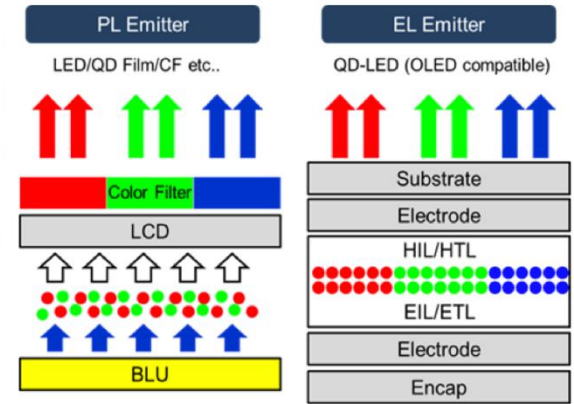


R. D. Schaller, and V. I. Klimov, *Phys. Rev. Lett.*, 92, 186601 (2014)

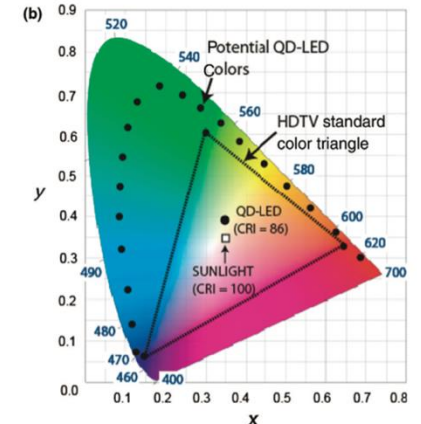
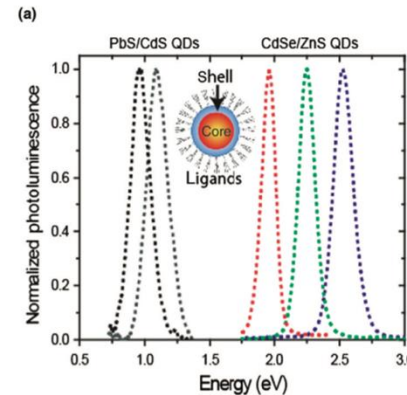
LED/Display



QD Vision



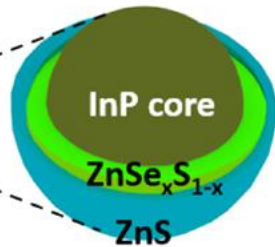
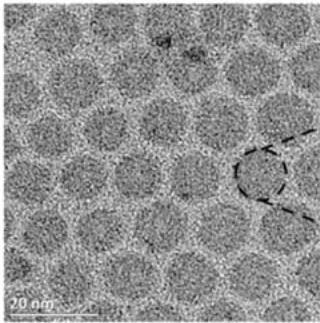
- ✓ Promise color purity via size monodispersity



V. wood, and V. Bulovic, *Nano Review*, 1, 5202 (2010)

Potential for Optoelectronic Applications

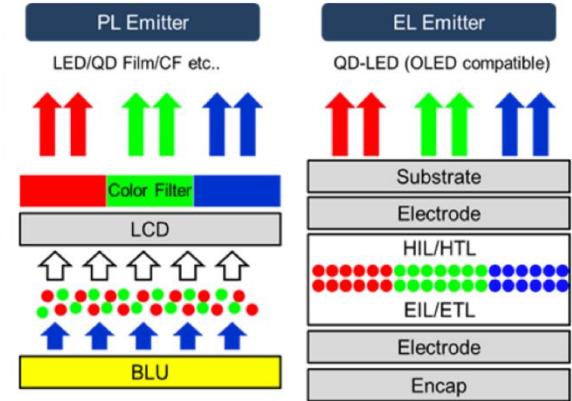
InP QDs



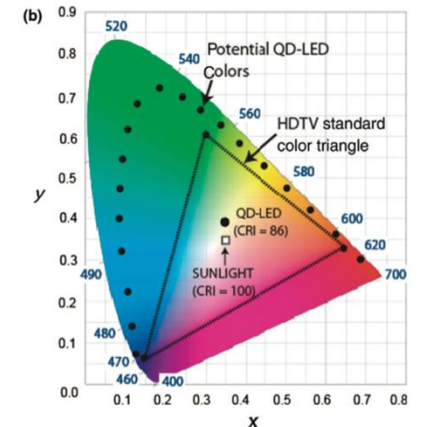
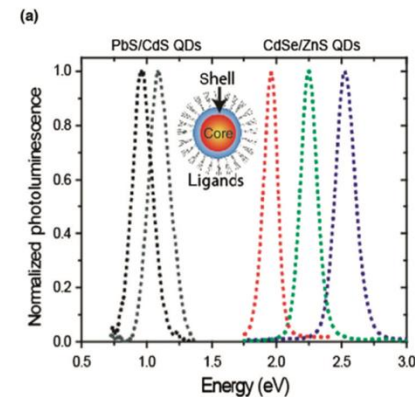
LED/Display



QD Vision



✓ Promise color purity *via* size monodispersity



V. wood, and V. Bulovic, *Nano Review*, 1, 5202 (2010)

Research Field

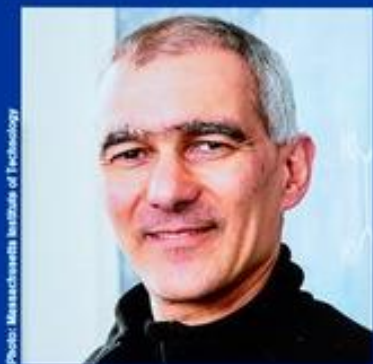


NOBELPRISET I KEMI 2023 THE NOBEL PRIZE IN CHEMISTRY 2023



KUNGL.
VETENSKAPS-
AKADEMIEN

THE ROYAL SWEDISH ACADEMY OF SCIENCES



Moungi Bawendi

Massachusetts Institute of Technology (MIT)
USA



Louis Brus

Columbia University
USA



Alexei Ekimov

Nanocrystals Technology Inc.
USA

"för upptäckt och syntes av kvantprickar"

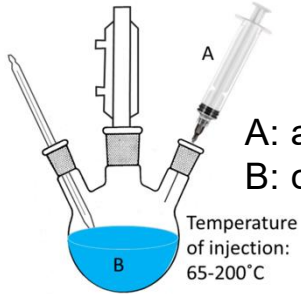
"for the discovery and synthesis of quantum dots"

Research Field

Synthesis

CIGS, AIGS, InP, CdSe, AgBiS₂, PbS, PbSe

- Hot injection

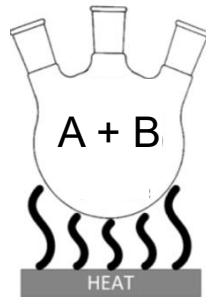


A: anion precursor
B: cation precursor

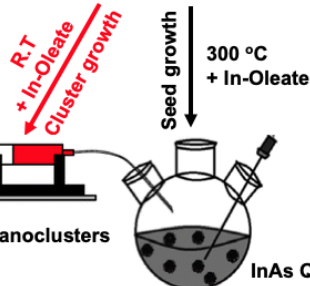
Temperature of injection:
65-200°C

- Heat-up

A: anion precursor
B: cation precursor



- Continuous injection

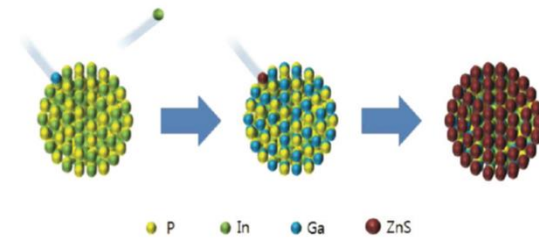


Amorphous InAs Nanoclusters

InAs QD Seeds

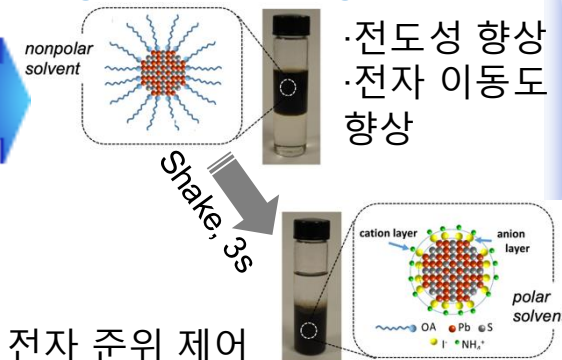
Surface Modification

- Core-shell (InP/GaP/ZnS)



● P ● In ● Ga ● ZnS

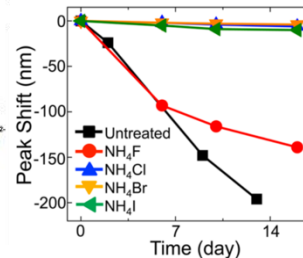
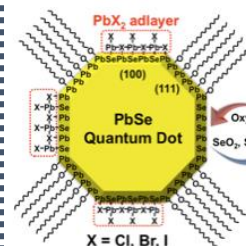
- Ligand exchange (ink)



·전도성 향상
·전자 이동도 향상

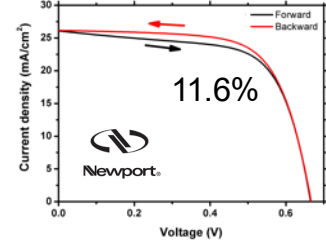
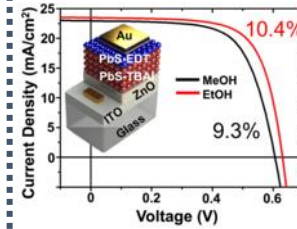
·전자 준위 제어
·페르미 준위 제어

- Selective adlayer formation
(대기 안정성 증대)

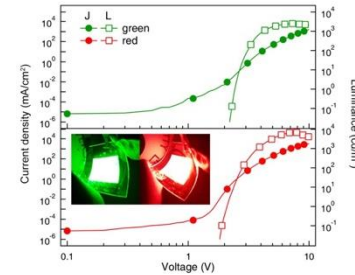
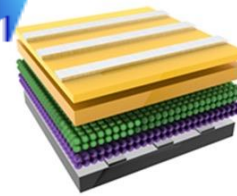


Device Applications

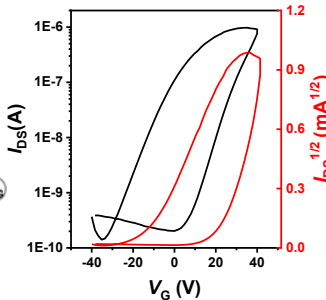
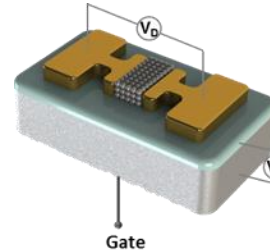
- PVs, PDs



- LEDs

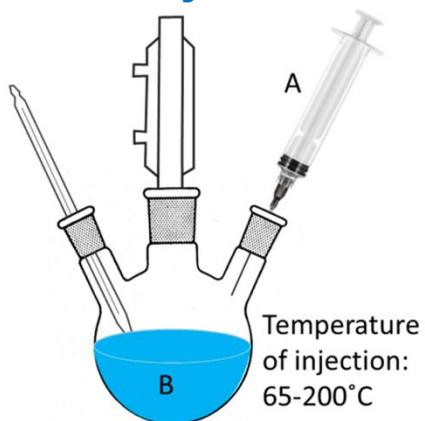


- FETs



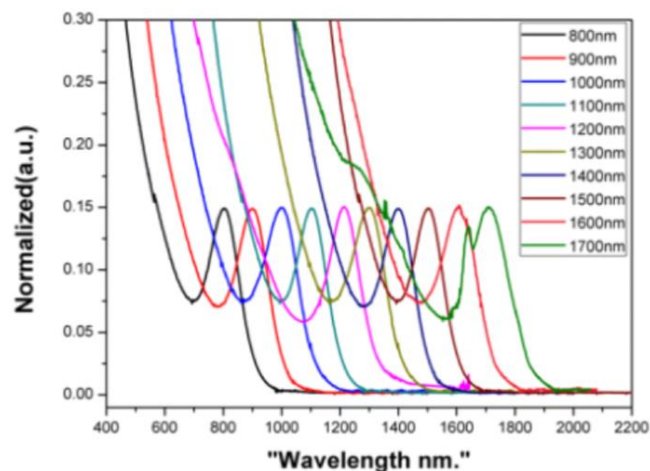
Colloidal Quantum Dot Synthesis

Hot injection

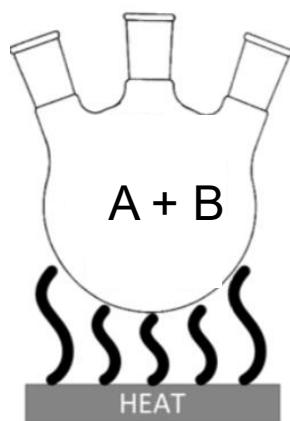


A: anion precursor
B: cation precursor

PbS, AgBiS₂, CuInGaSe₂

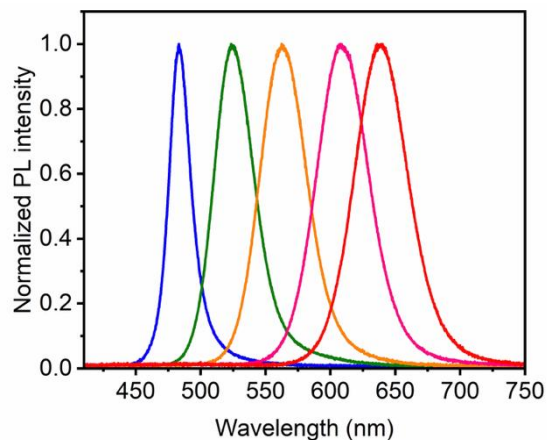


Heat-up



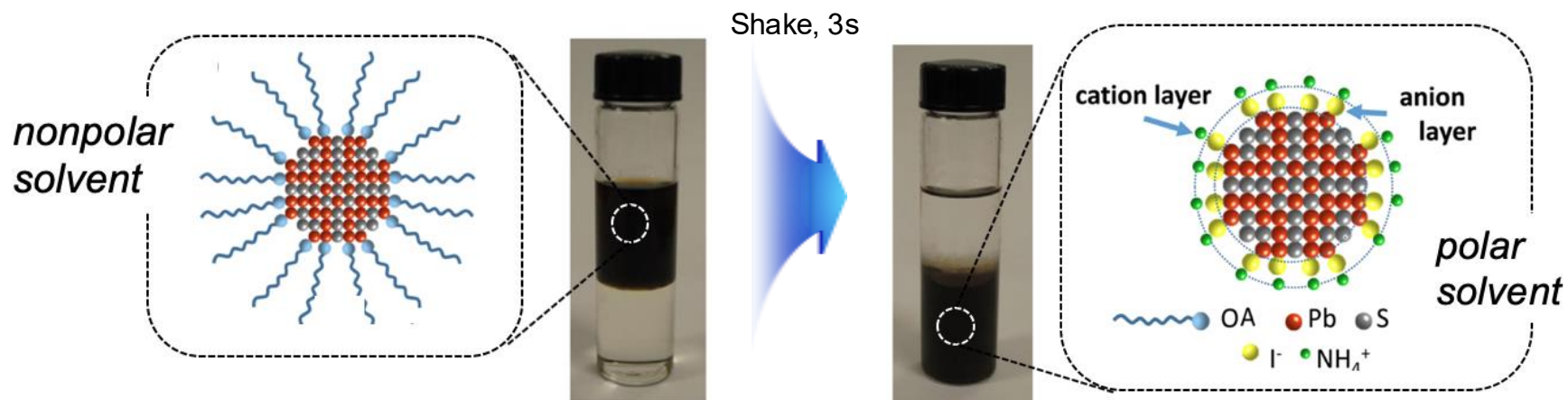
A: anion precursor
B: cation precursor

AgInGaS₂, InP

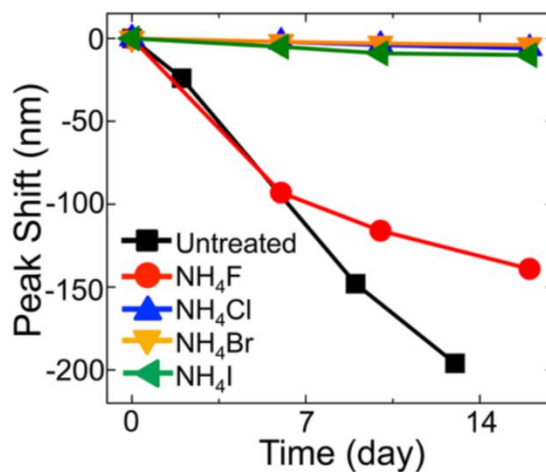
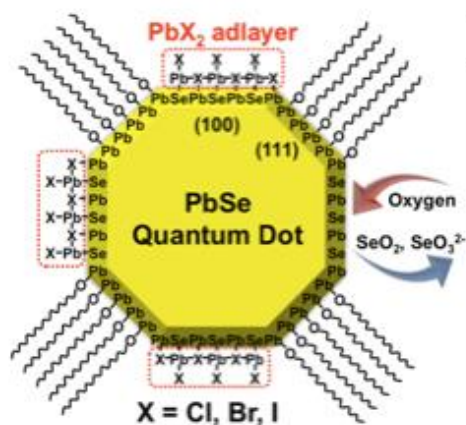


Surface Modification

Ligand exchange

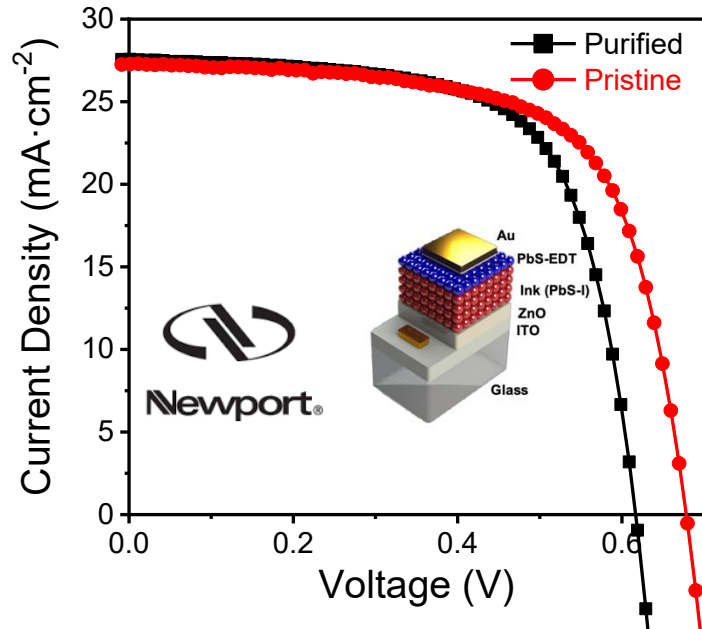


Adlayer formation (Core-shell)

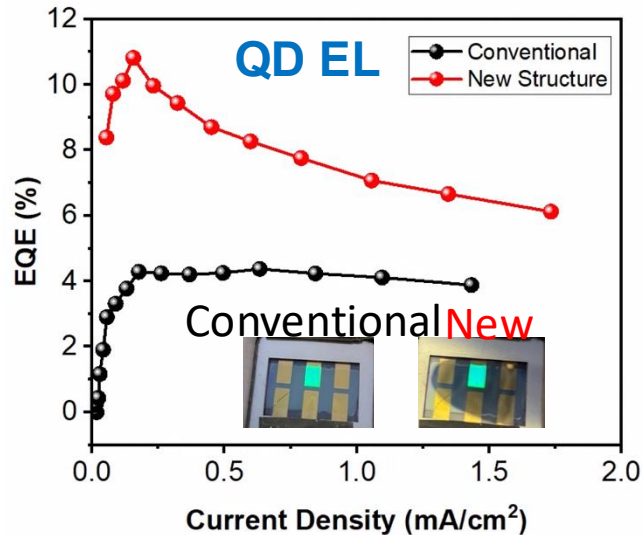
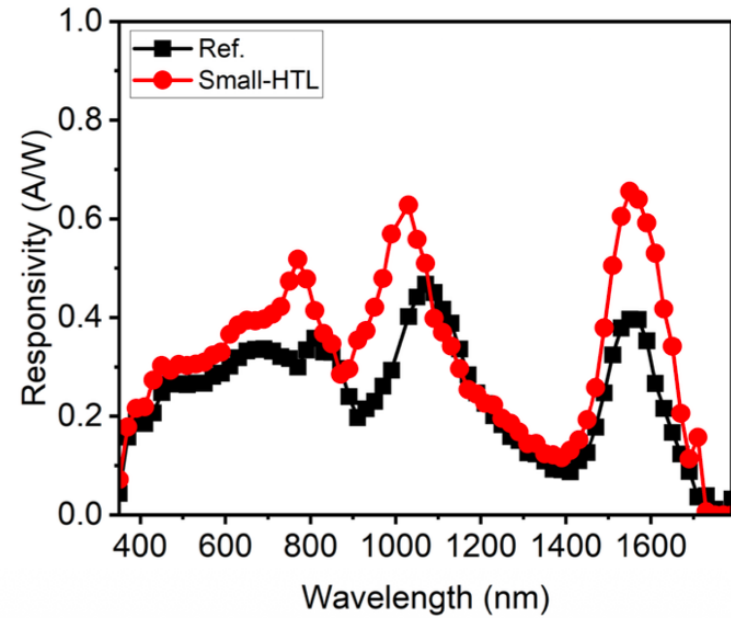


Optoelectronic Applications

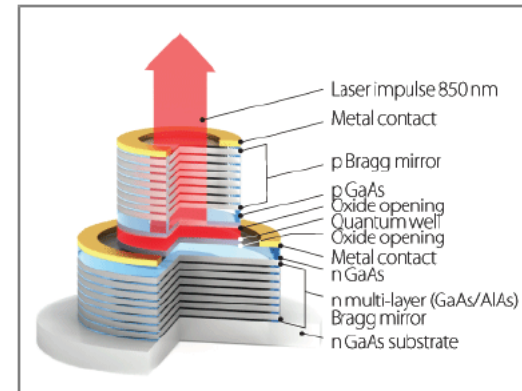
Photovoltaics



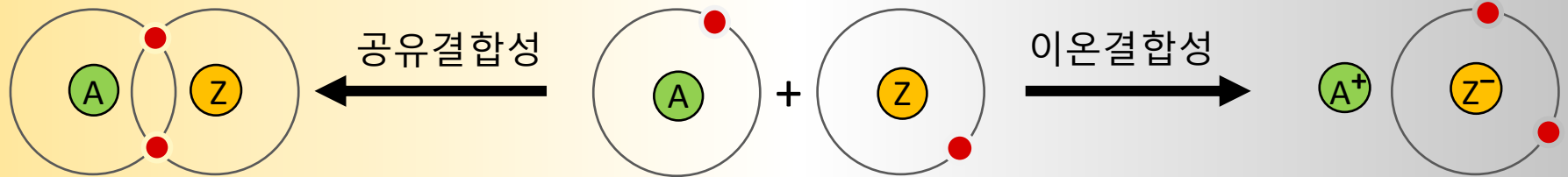
Photodiodes



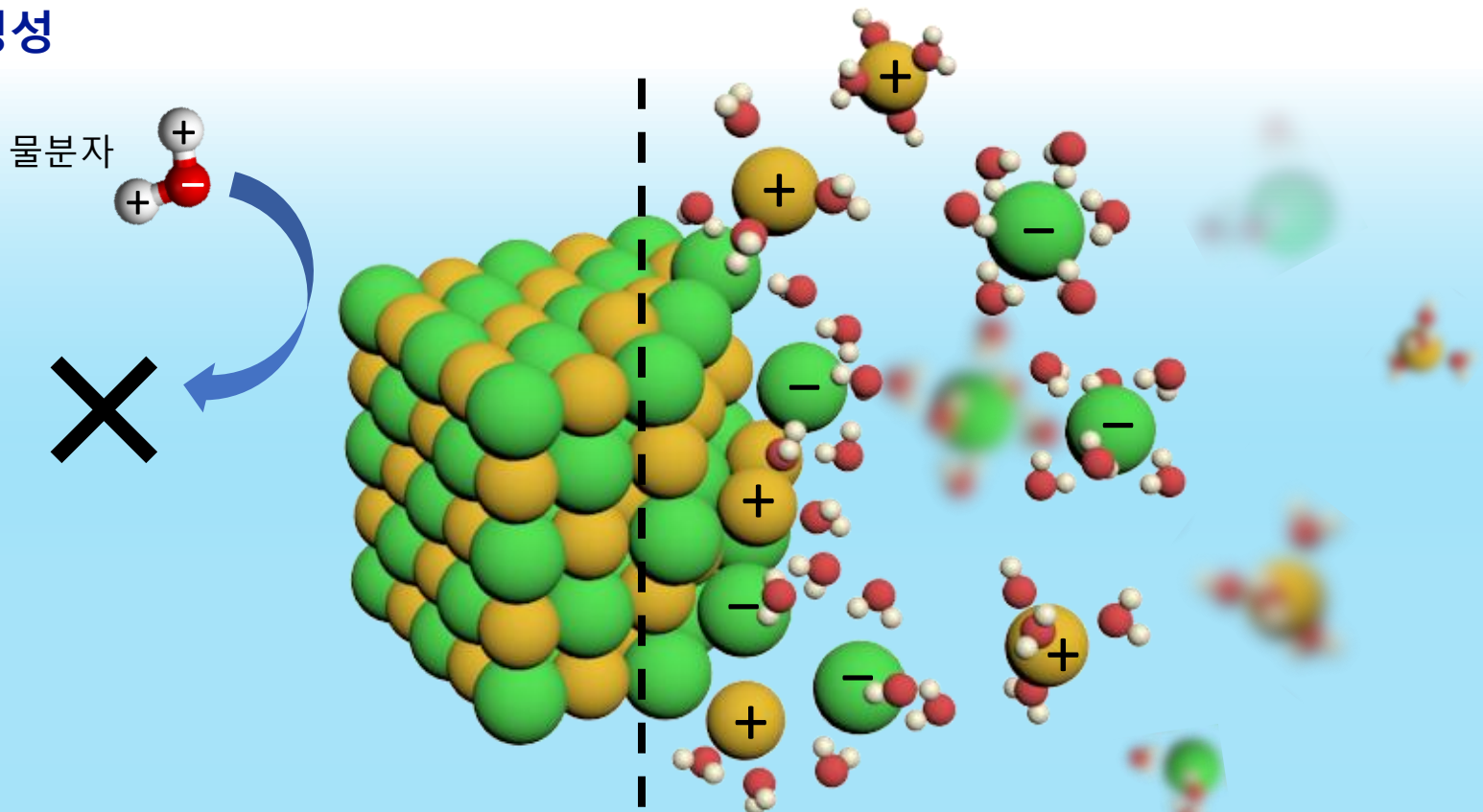
LASER



Quantum Dots with Ionic Crystal



화학적 안정성



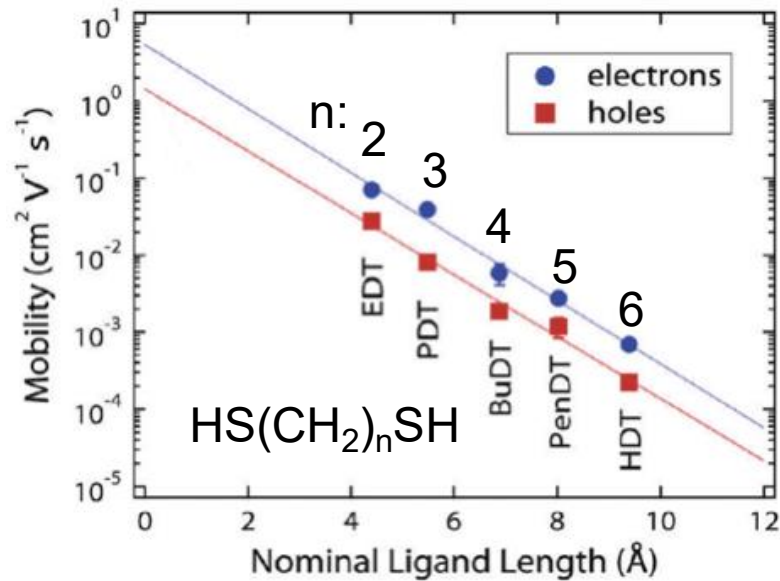
다양한 화학적 스트레스에 안정함
안정한 저독성 소재 ←

손쉬운 표면 제어와 용해
→ 안정성 및 생체 독성 문제

Properties Depending on Surface Modification

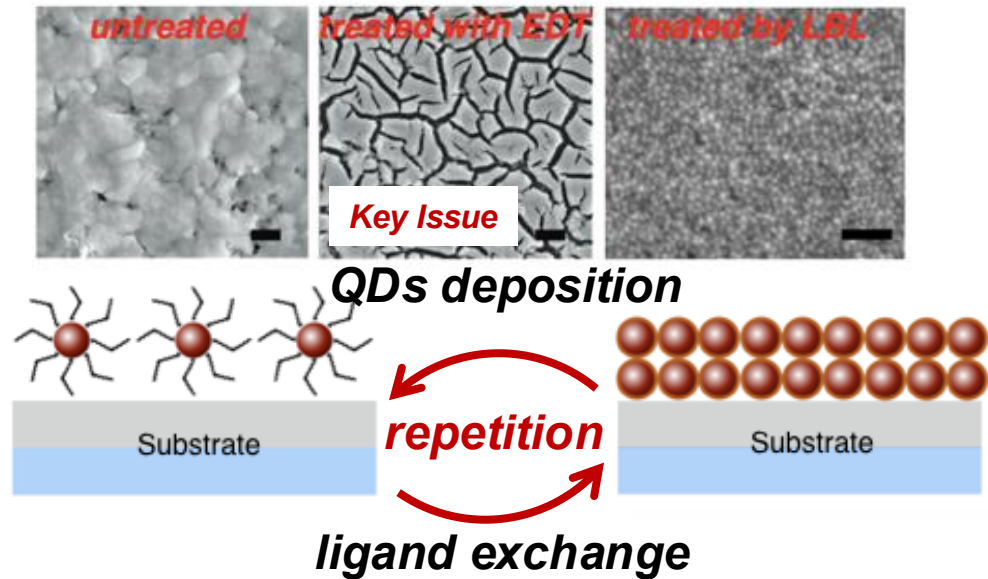
Ligand-dependent Mobility

Liu et al., Nano Lett., 2009, 10, 1960



Layer-by-layer (LBL) Process

Luther et al., ACS Nano, 2008, 2, 271



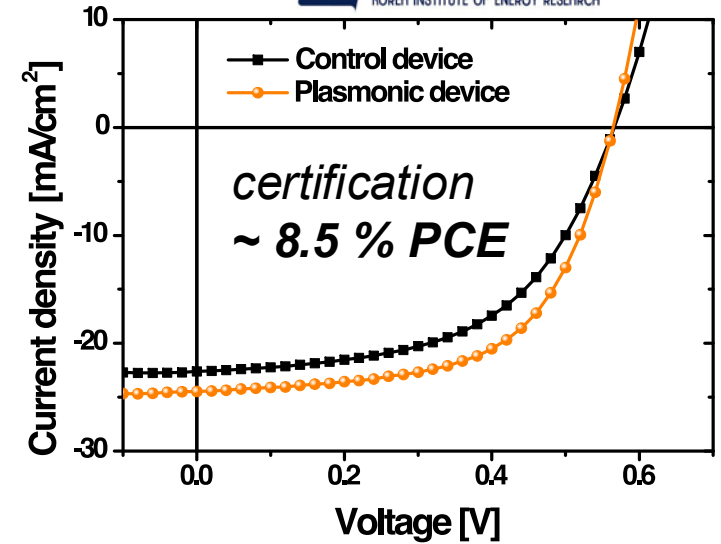
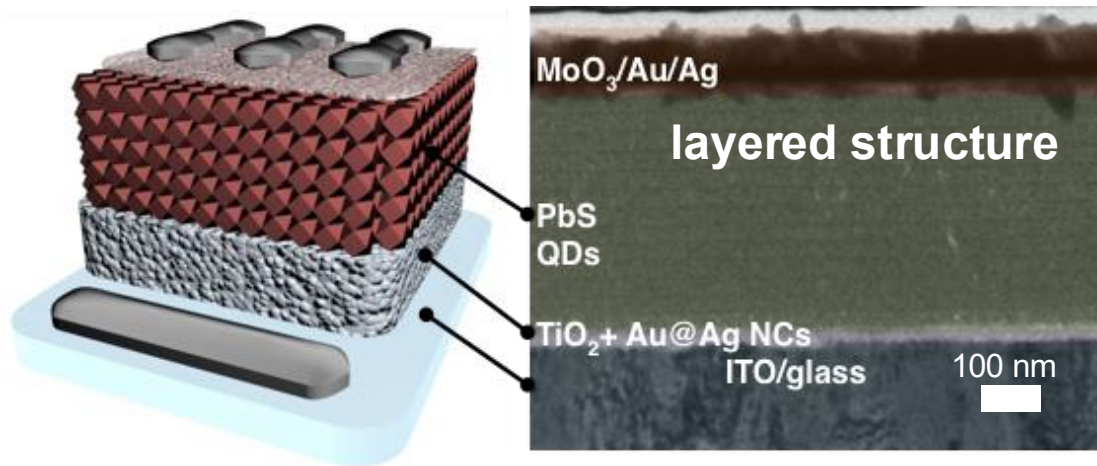
- 양자점 기반 응용소자의 동작 원리에 따라 물성 제어 필요
- 수광소자 (태양전지 및 광센서)의 경우 높은 전도도 요구
- 짧은 리간드로 교환 시, 박막의 갈라짐 발생

Properties Depending on Surface Modification

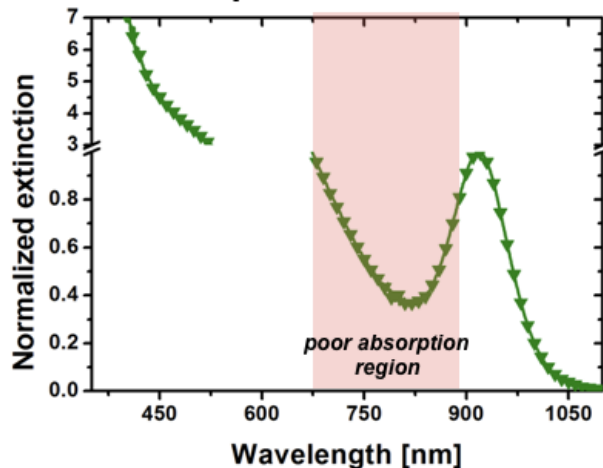
CQD Solar Cell using LBL Process

J. H. Song, et al., *Adv. Mater.*, 2015, 27, 8102

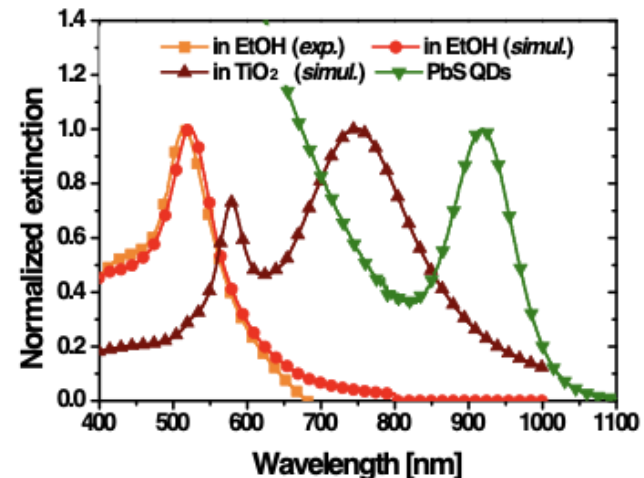
KIER 한국에너지기술연구원
KOREA INSTITUTE OF ENERGY RESEARCH



External quantum efficiency & absorption in solar cells

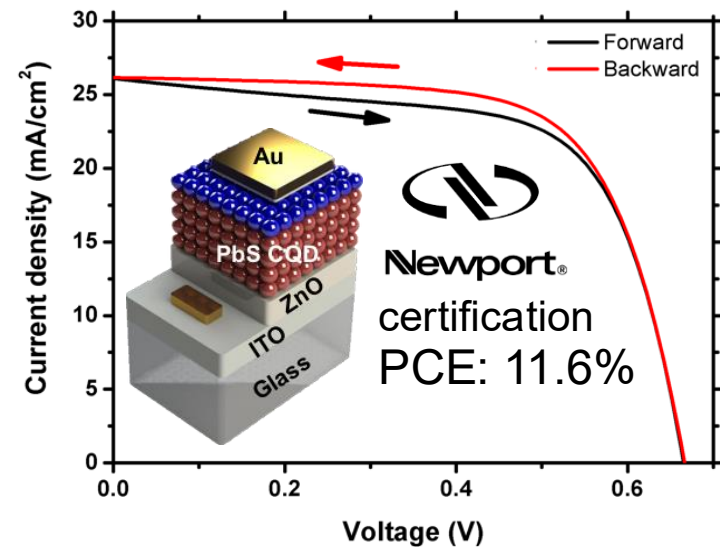
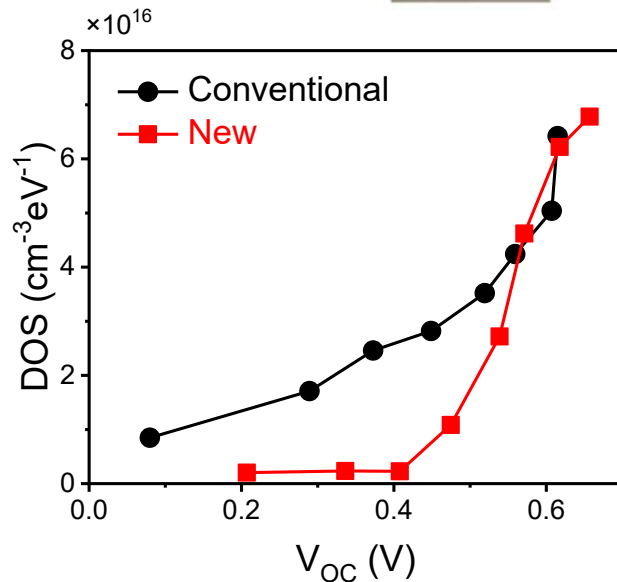
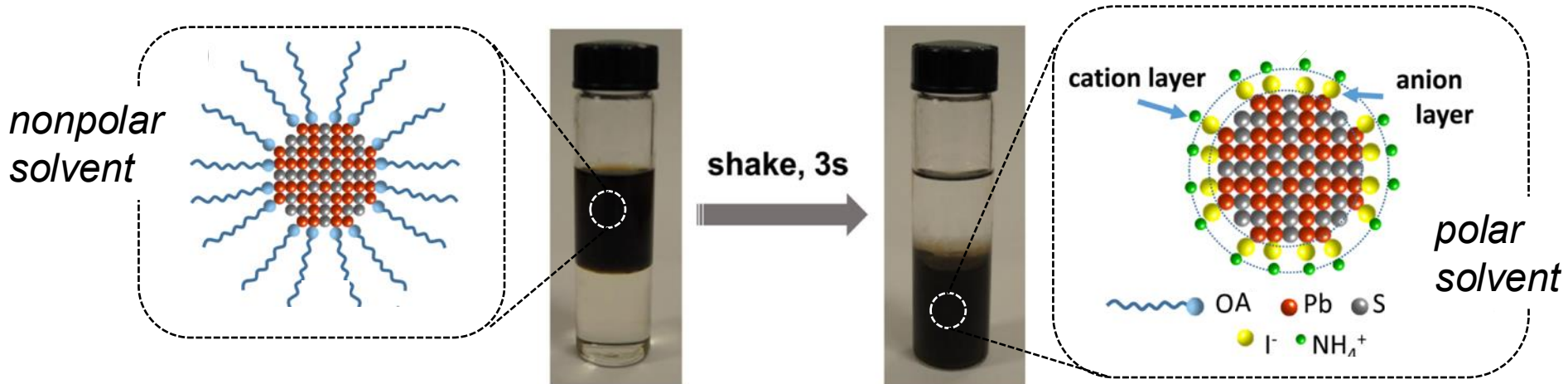


NCs scattering in TiO₂ & QD abs.



Surface Modifications for Efficient PVs (trap density)

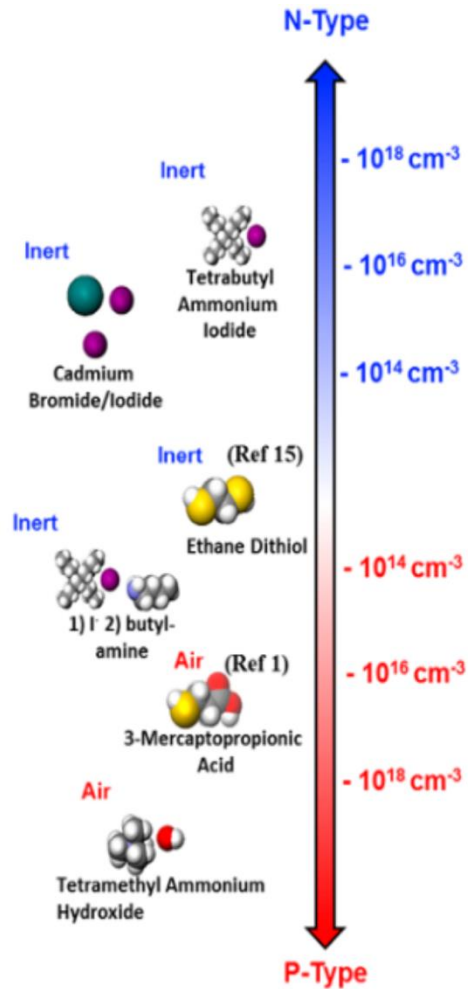
Control of surface defects by solution phase ligand exchange
(Diffusion length)



Properties Depending on Surface Modification

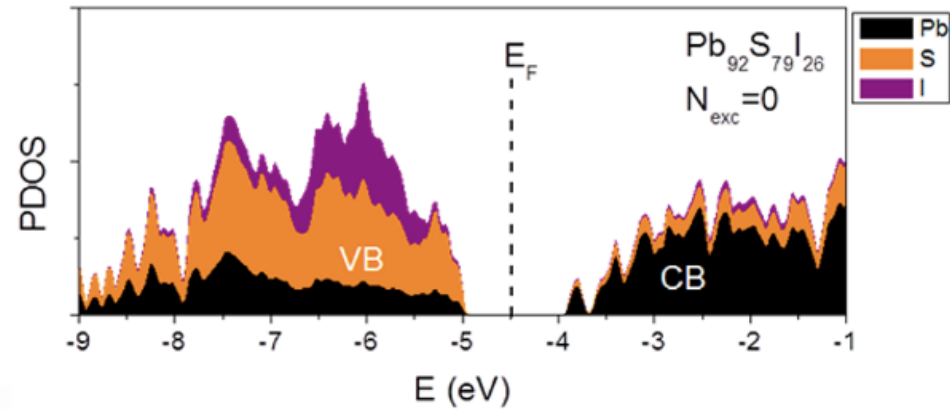
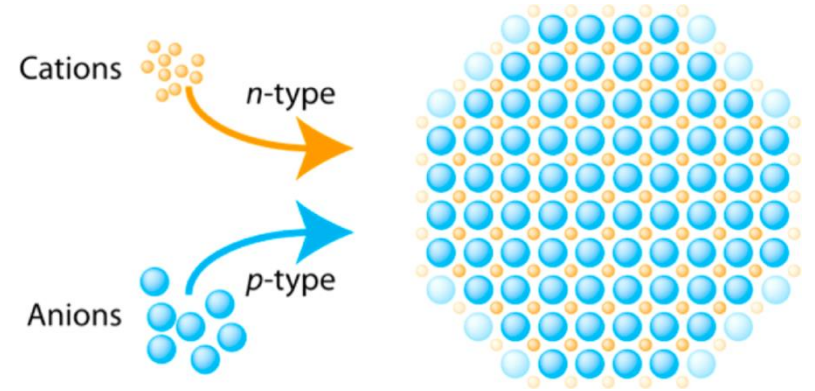
Ligand-dependent Doping

Voznyy et al., *ACS Nano*, 2012, 6, 8448



Stoichiometry Doping

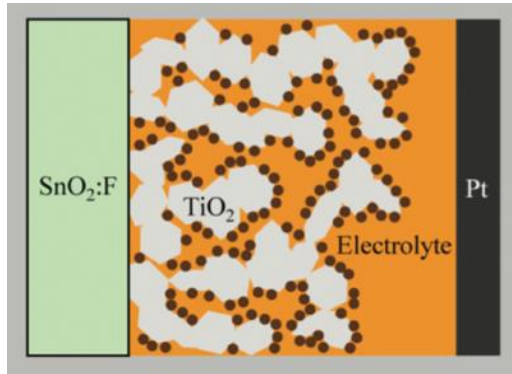
Bozyigit et al. *Nat. Commun.* 2015, 6, 6180



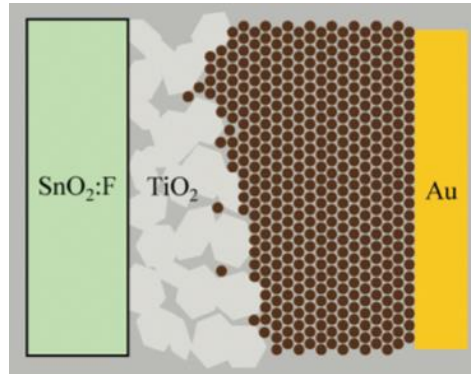
Surface Modifications for efficient PVs (doping)

Various structures of quantum dot solar cells

CQD-sensitized solar cell
(LED 소자와 동작 원리 유사)



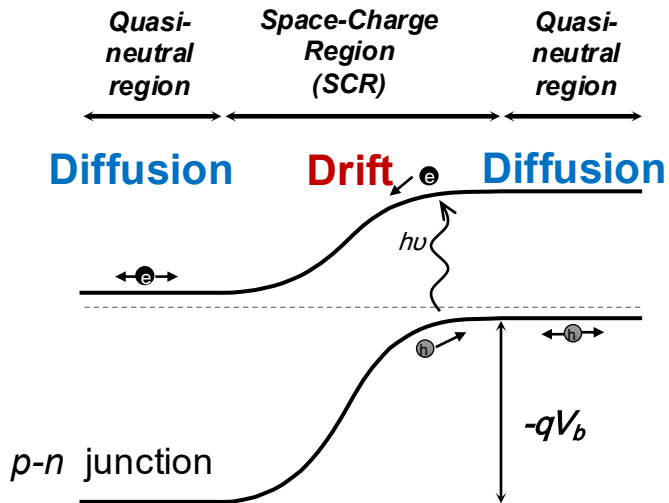
CQD thin film solar cell



장점
우수한 광 흡수

단점
양자점들간 전하 이동
고려 (전기적 물성 제어
필수)

Operating principle of thin-film quantum dot solar cell



전하의 이동

- **Drift** region : Doping concentration, Energy level etc.
- **Diffusion** region : Trap density, Mobility, etc.

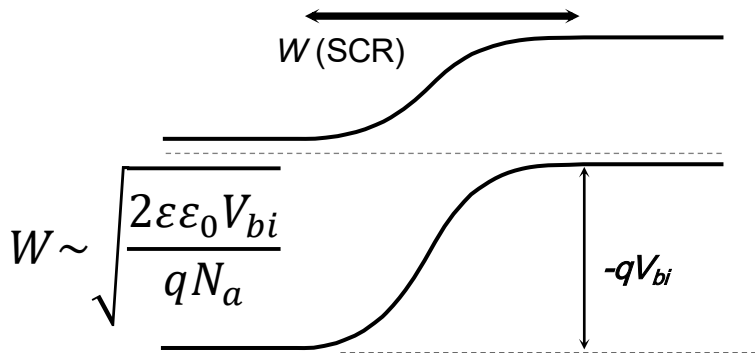
박막형 양자점 태양전지 → **Drift solar cells***

Drift region (~300 nm) > **Diffusion** region (~100 nm)

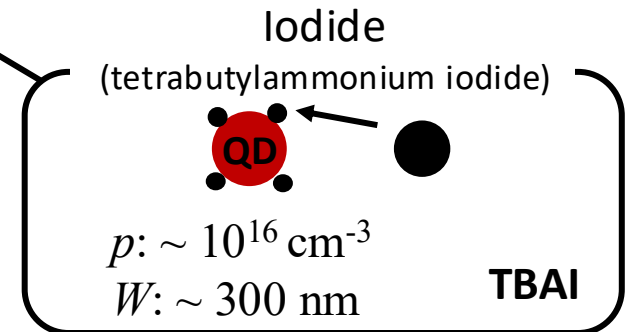
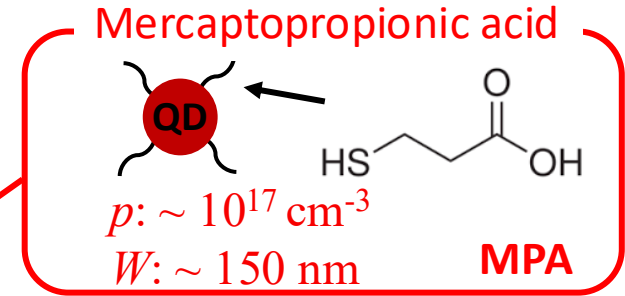
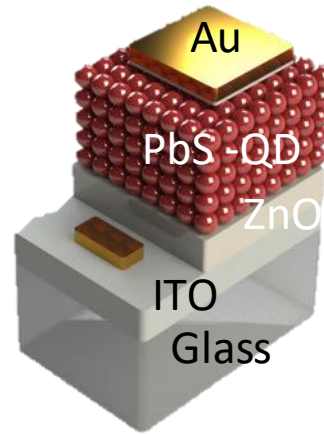
Surface Modifications for efficient PVs (doping)

Space charge region increase by doping concentration (**Drift region**)

표면 리간드에 따른 도핑 농도 및 SCR 영역 변화

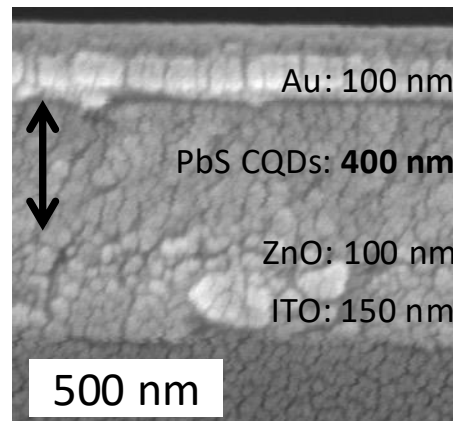
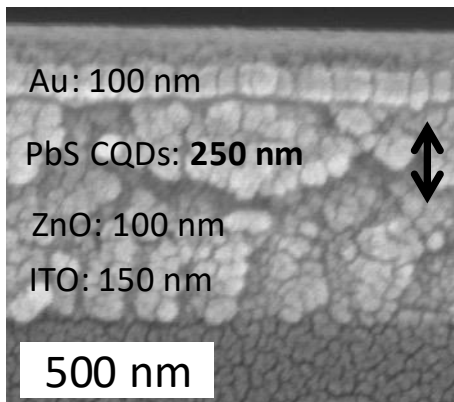


넓은 SCR 영역 ~ 낮은 도핑 농도

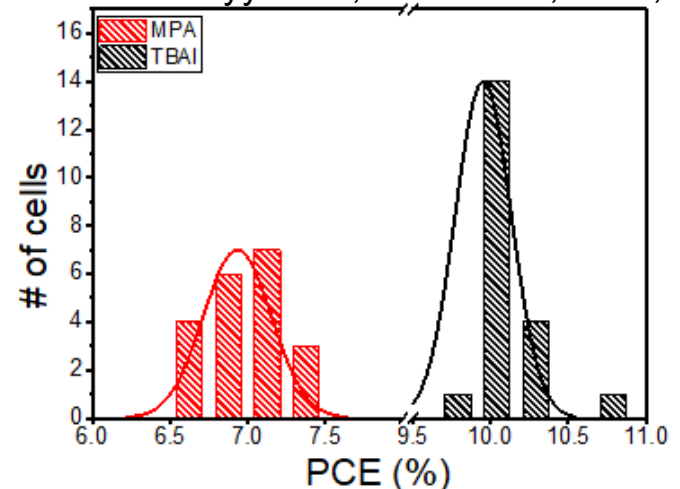


MPA

TBAI



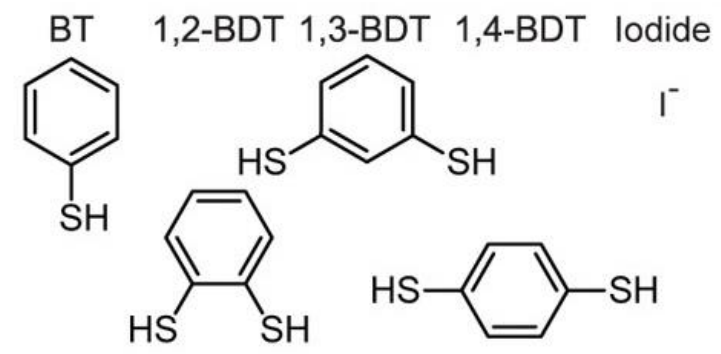
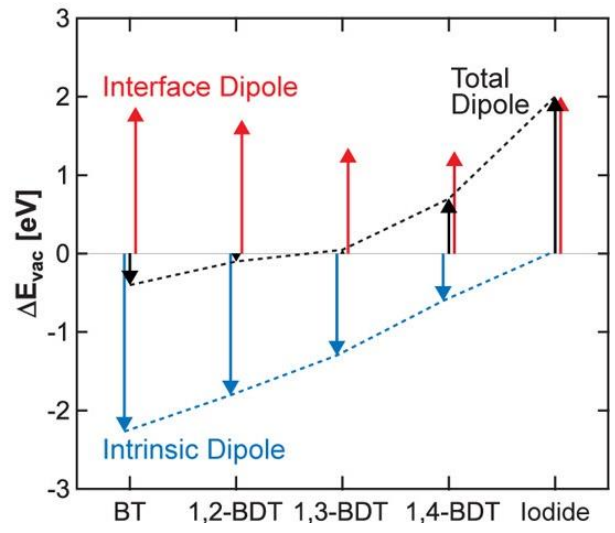
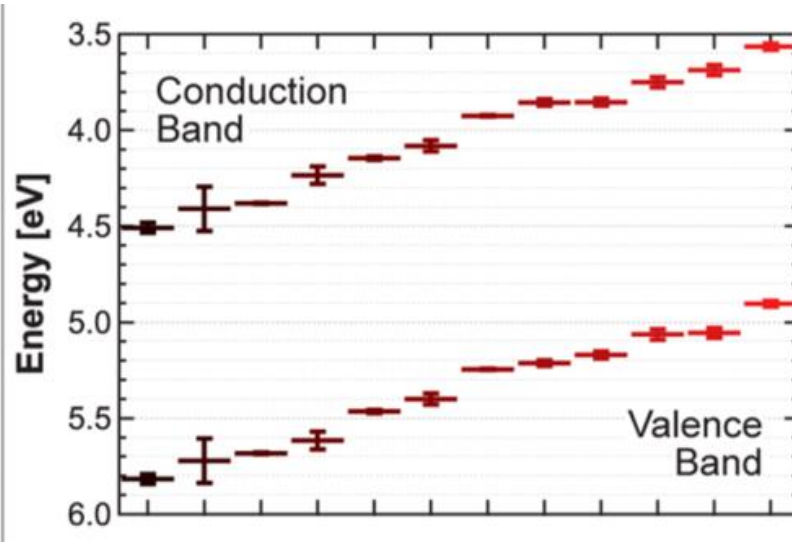
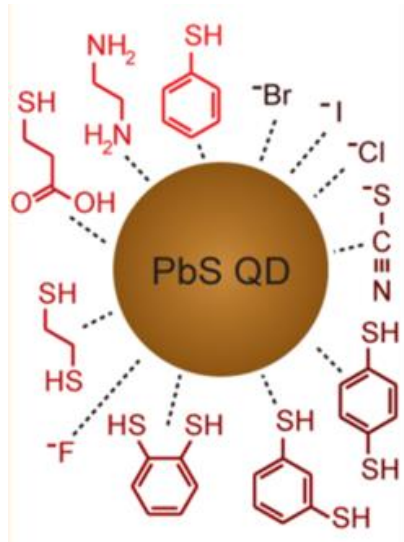
Voznyy et al., *ACS Nano*, 2012, 6, 8448



Properties Depending on Surface Modification

Ligand-dependent Energy Level

Brown et al., ACS Nano, 2014, 8, 5863

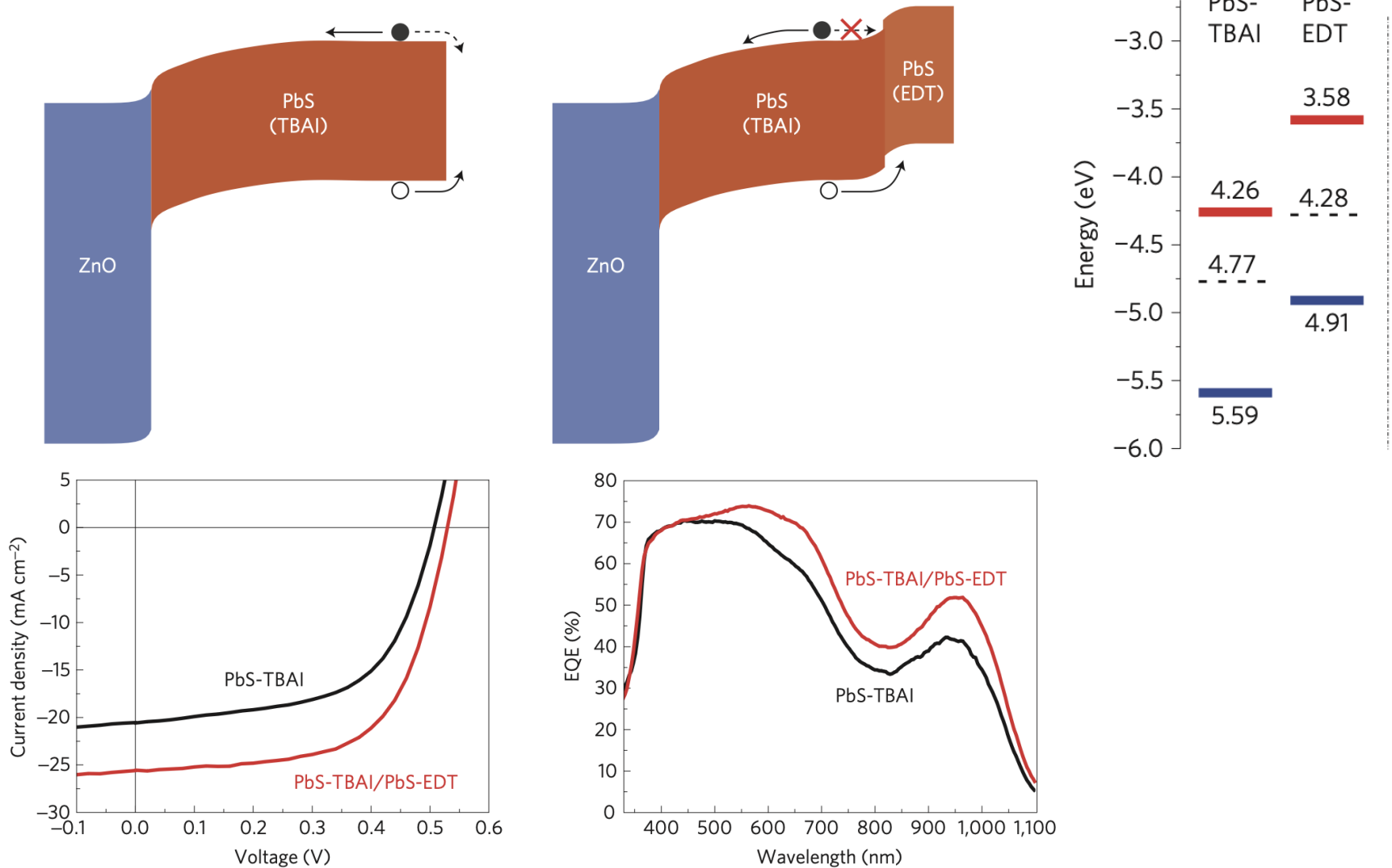


- 표면 리간드 결합에 의한 전자 재분포
→ surface dipole moment

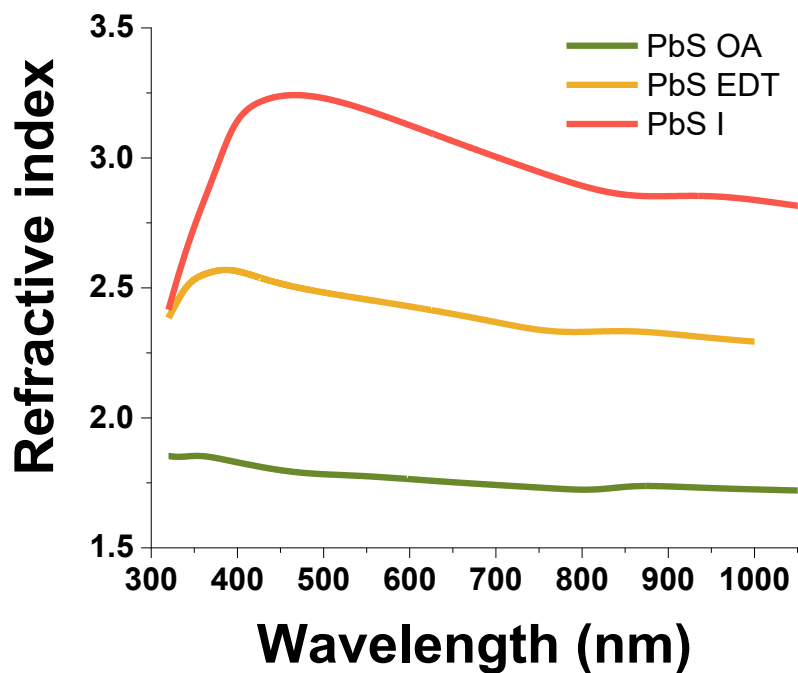
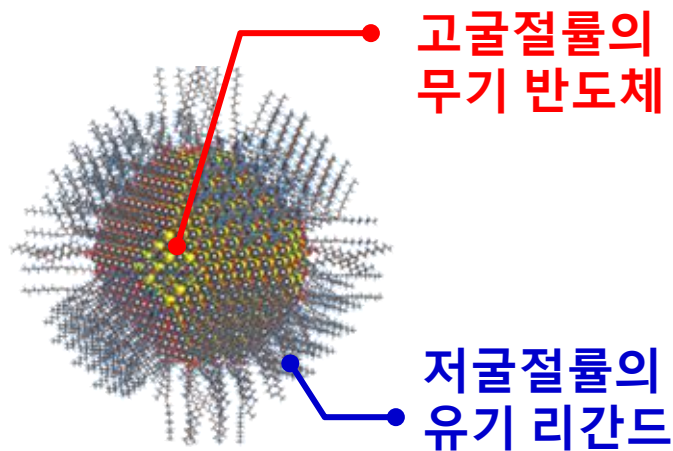
Properties Depending on Surface Modification

Improved performance through band alignment engineering

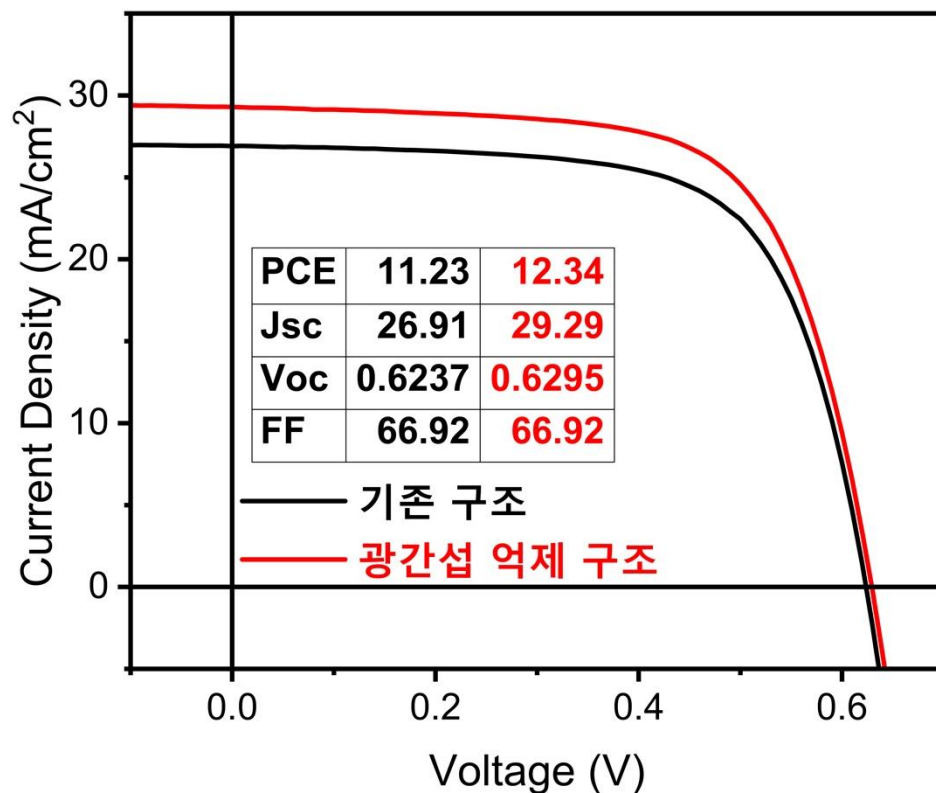
C. M. Chuang et al., Nat. Mater., 2014, 13, 796



Control of optical Properties by Surface Modification

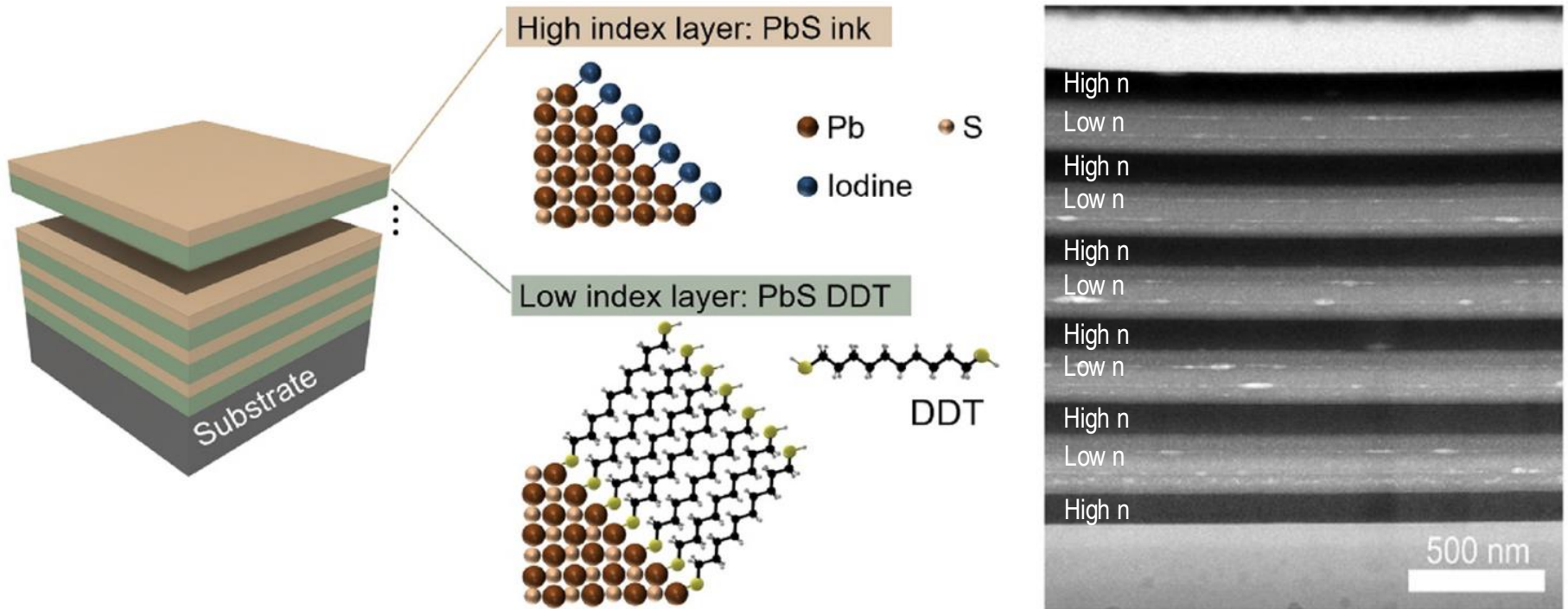


Reflection suppression structure using **refractive index control** of QDs



Paper in preparation

Control of optical Properties by Surface Modification



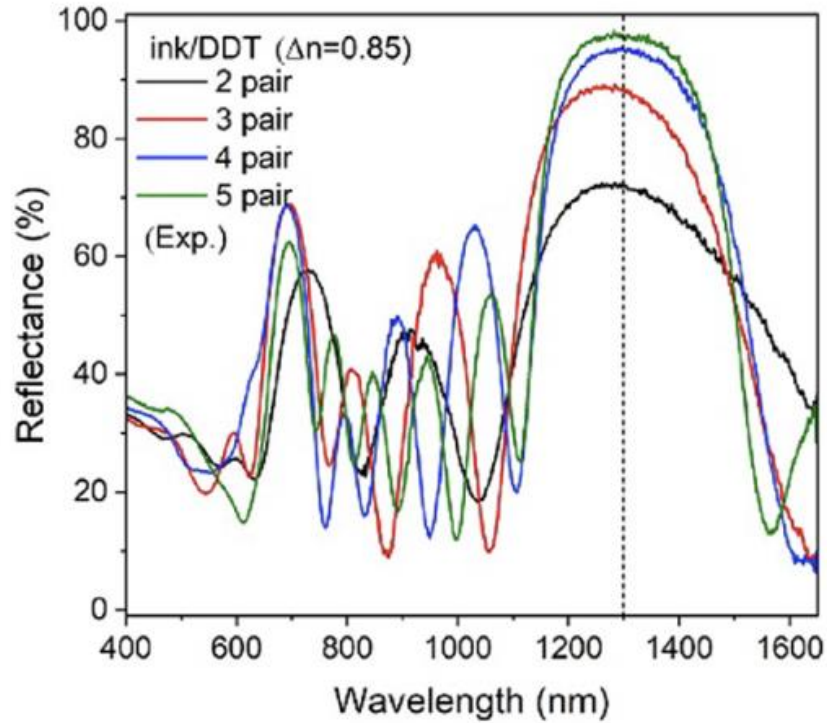
$$n_H d_H + n_L d_L = \frac{\lambda_C}{2} \rightarrow \lambda_C = 1300 \text{ nm}$$

$$d_H \sim 121 \text{ nm}$$

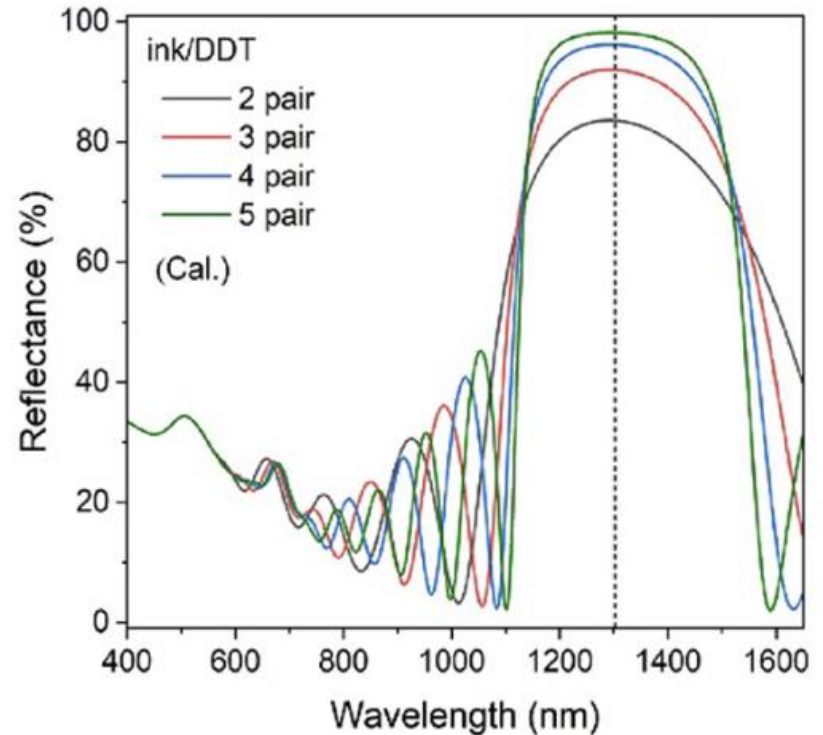
$$d_L \sim 177 \text{ nm}$$

Fabrication of Quantum Dot DBR

Experimental Results



Calculation Results



Ink/DDT $\rightarrow \Delta n = 0.85$

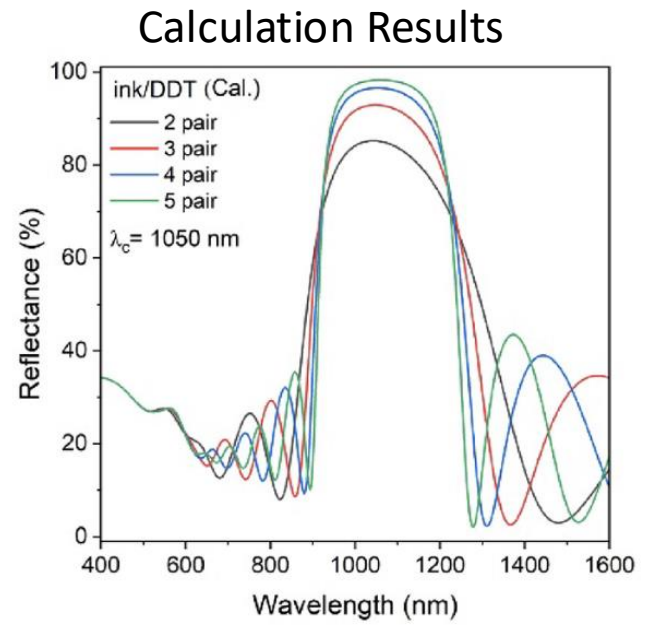
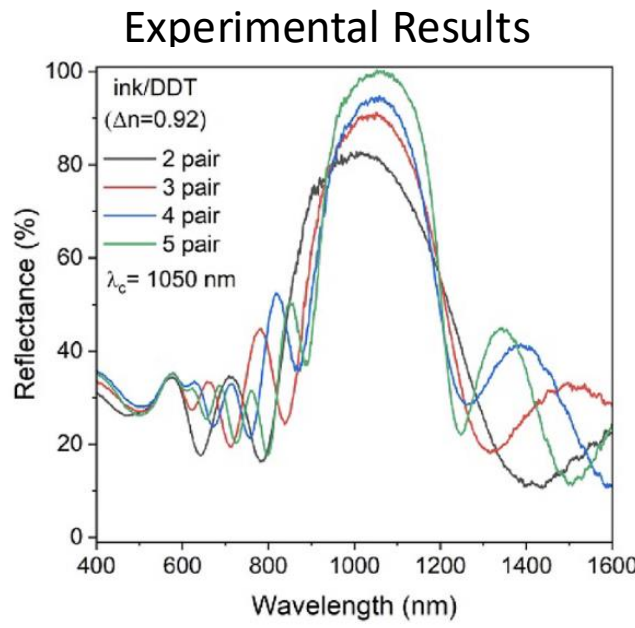
$$n_H d_H + n_L d_L = \frac{\lambda_C}{2} \rightarrow \lambda_C = 1300 \text{ nm}$$

$$d_H \sim 121 \text{ nm}$$

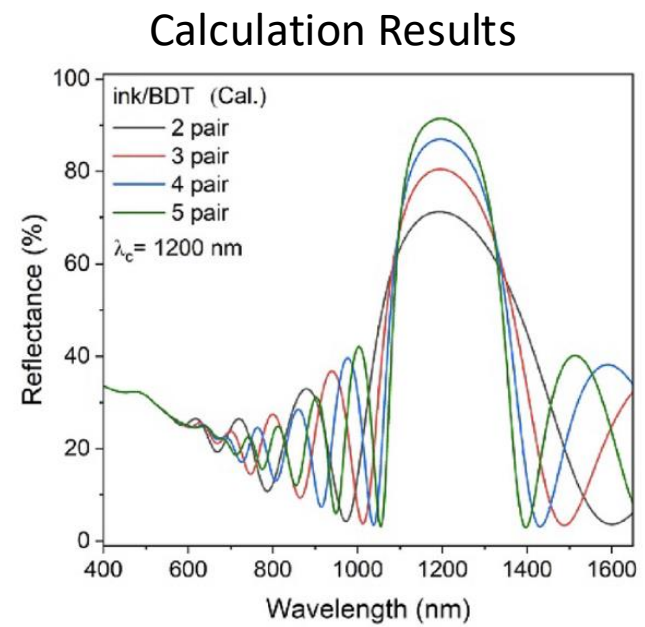
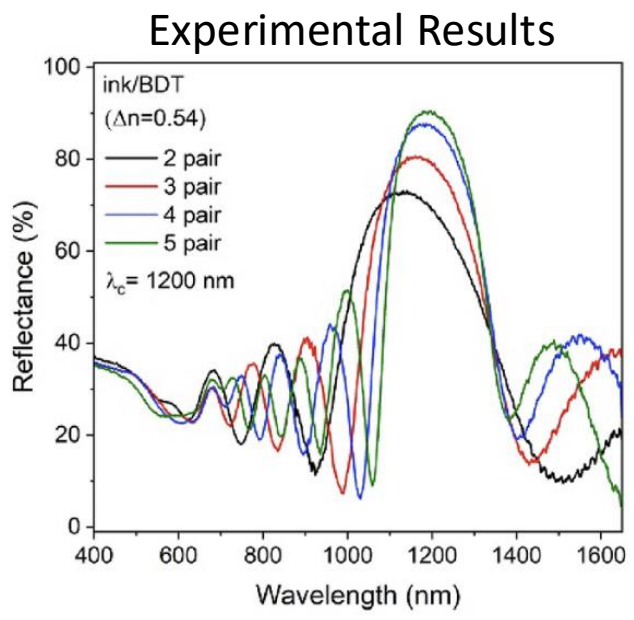
$$d_L \sim 177 \text{ nm}$$

Fabrication of Quantum Dot DBR

$\lambda_c = 1050 \text{ nm}$
Ink/DDT ($\Delta n = 0.92$)



$\lambda_c = 1200 \text{ nm}$
Ink/BDT ($\Delta n = 0.54$)



Tunable Infrared Bragg Reflectors of Entirely Ligand-Engineered Lead Sulfide Quantum Dot Layers

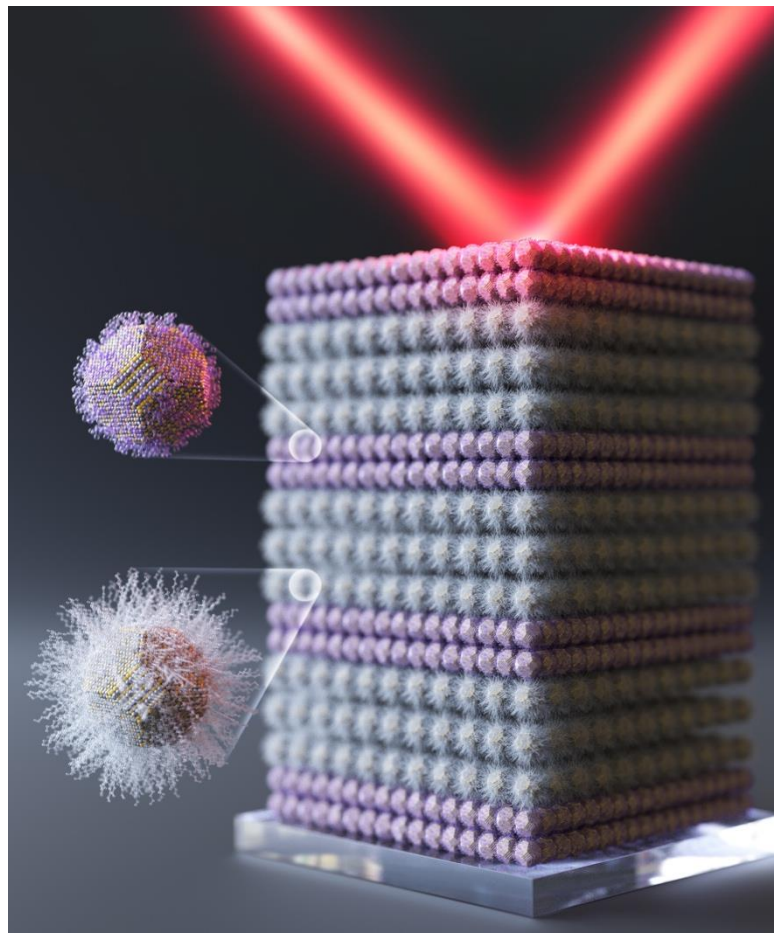
Jung Hoon Song, Jugyoung Kim, Moses Kim, Jung-Gyu Park, and Jang-Won Kang*



Cite This: <https://doi.org/10.1021/acs.jpcc.5c06300>



Read Online



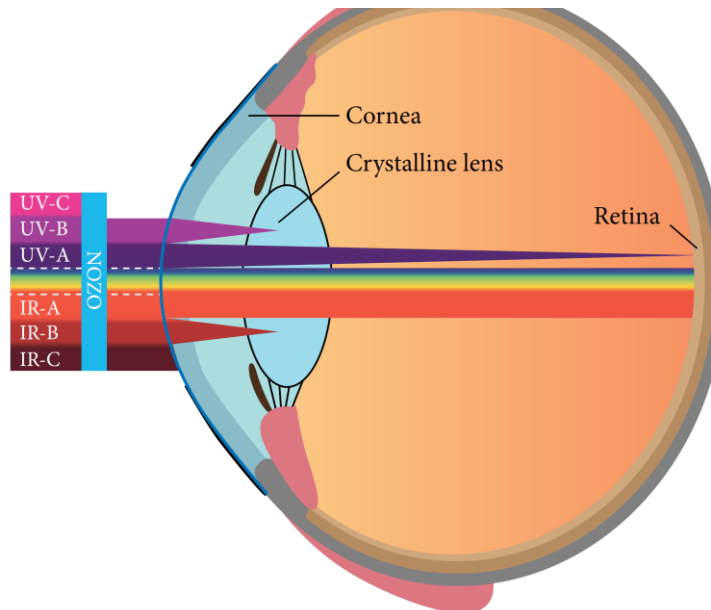
Emerging Applications of CQD Devices

Wireless Charging Systems



Eye-Safety Sensor Systems

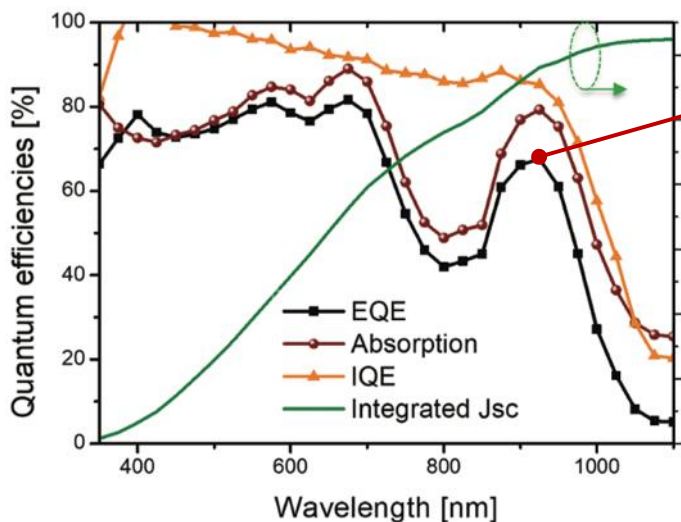
Short-Wave IR (SWIR)
1400 ~ 2500 nm



Near IR (NIR)
750 ~ 1400 nm

Emerging Applications of CQD Devices

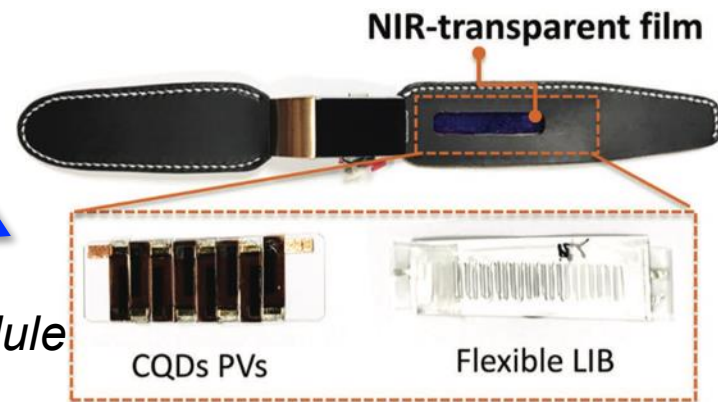
Wireless Charging System Using NIR



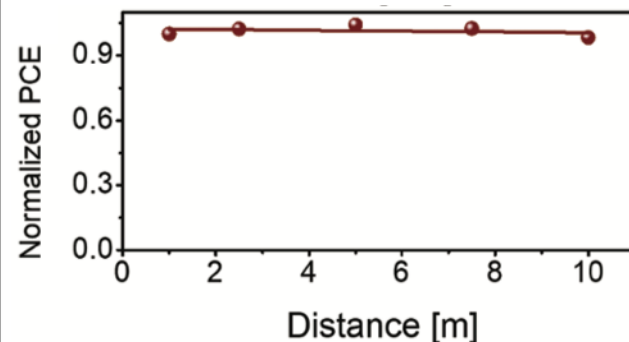
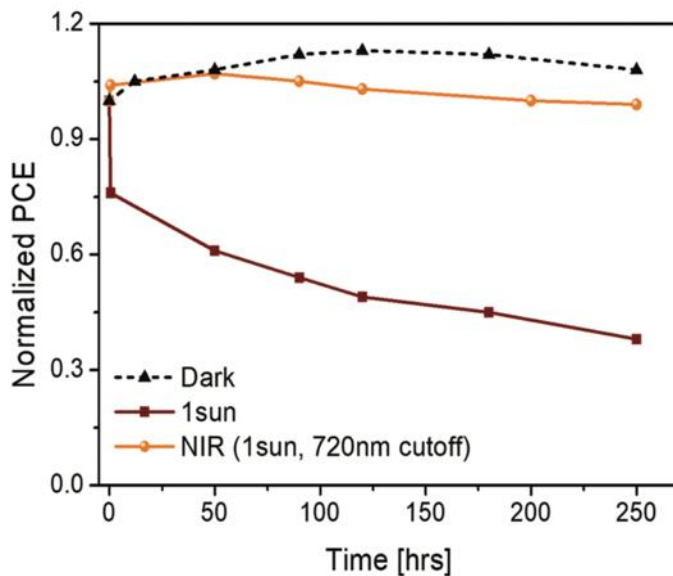
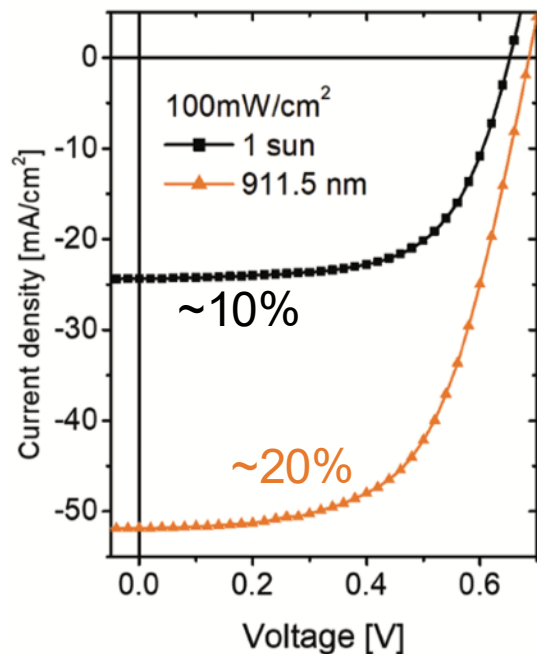
target: ~ 910nm



Photovoltaics module
integrating 8 cells



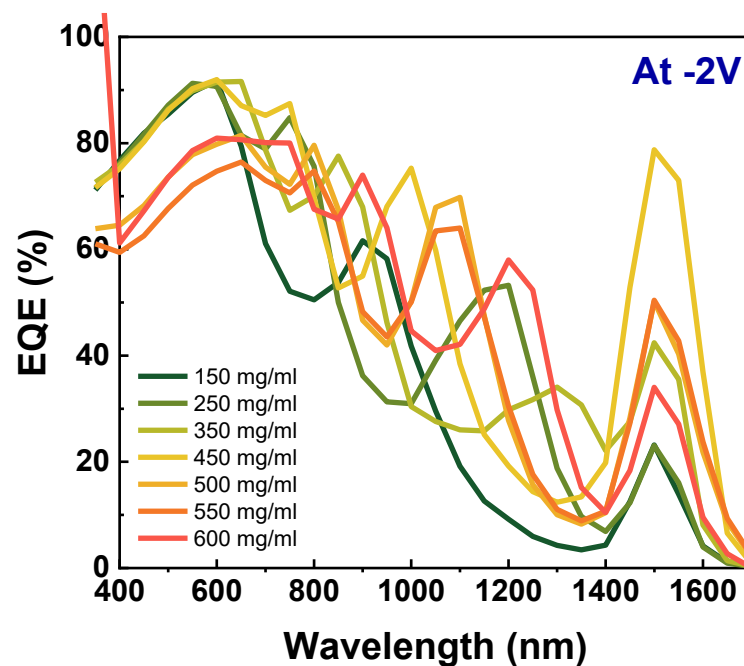
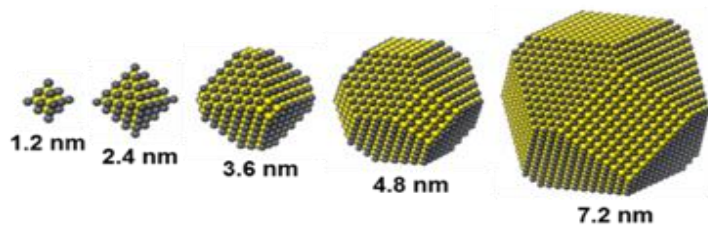
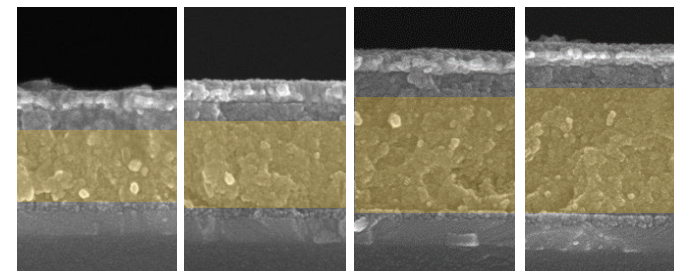
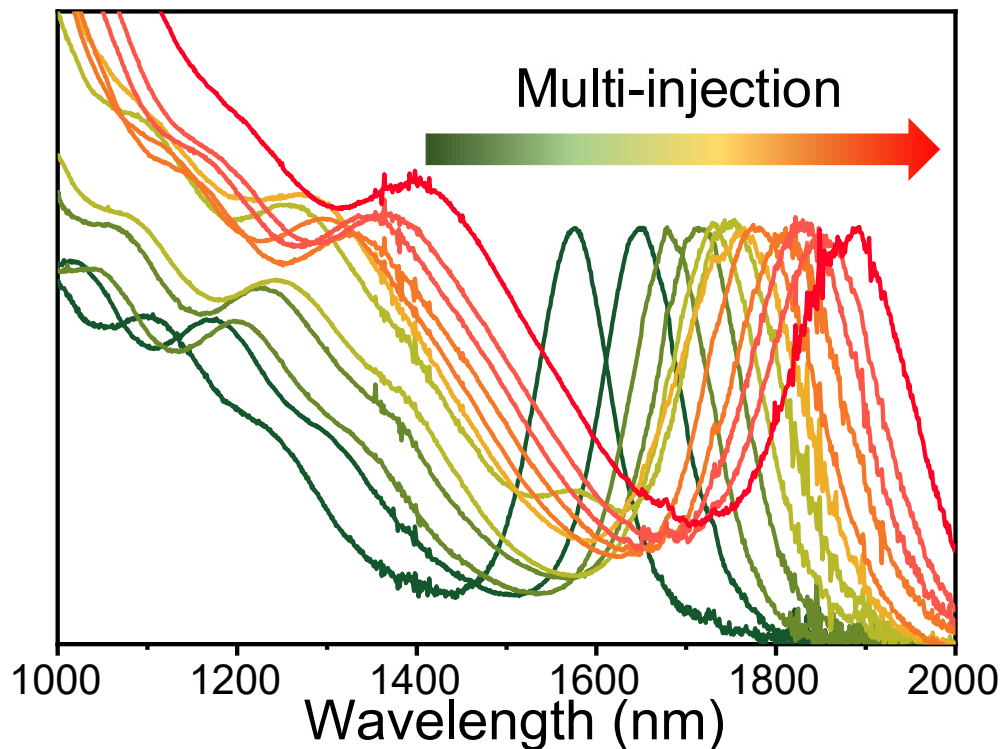
New structure



Efficient & Stable
operation in NIR

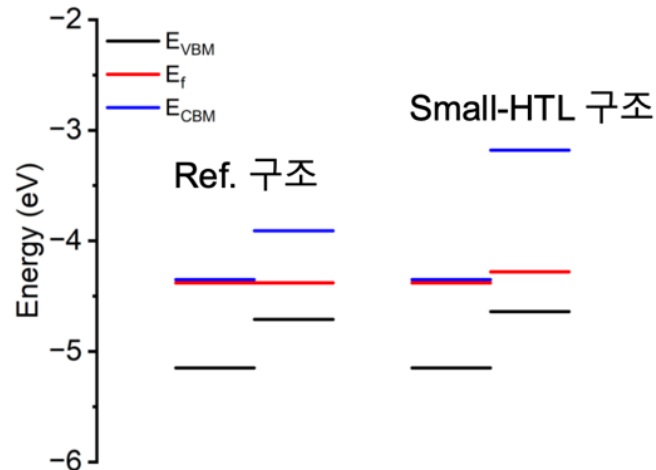
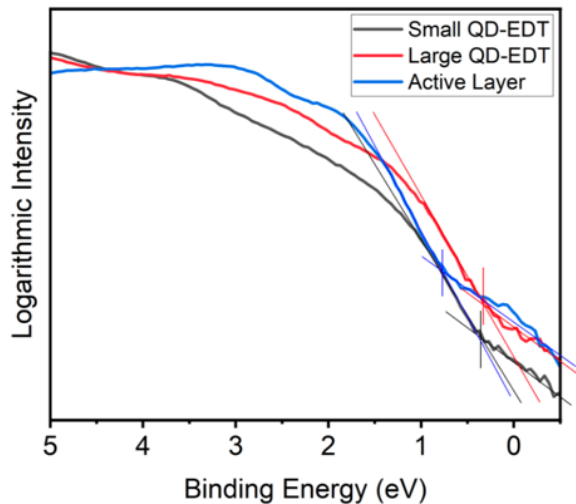
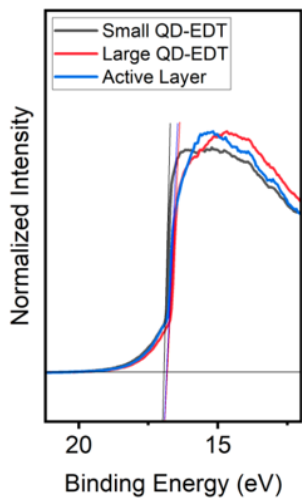
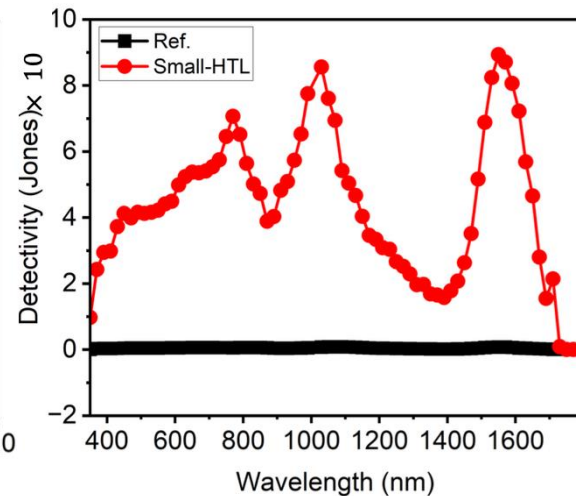
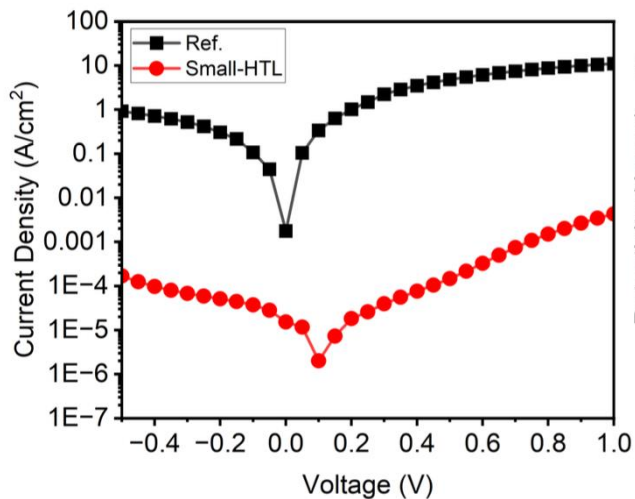
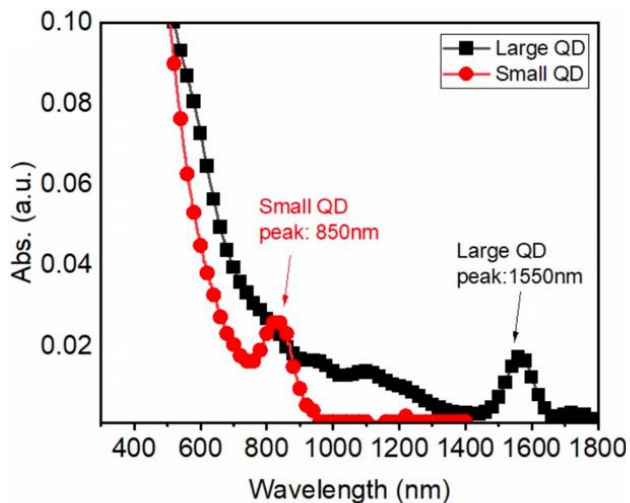
Emerging Applications of CQD Devices

Eye-Safety Sensor System Using CQDs

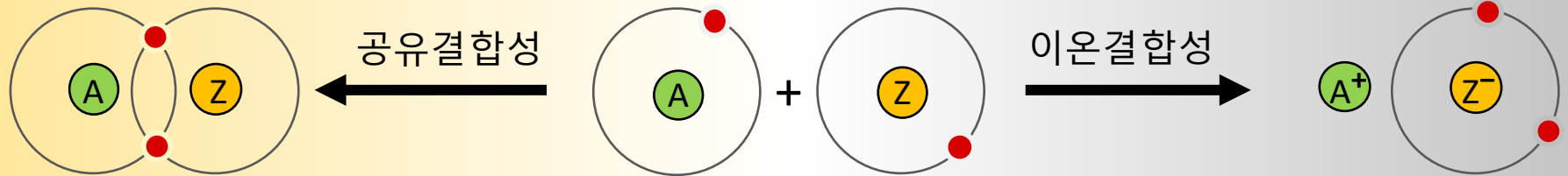


Band Alignment Engineering

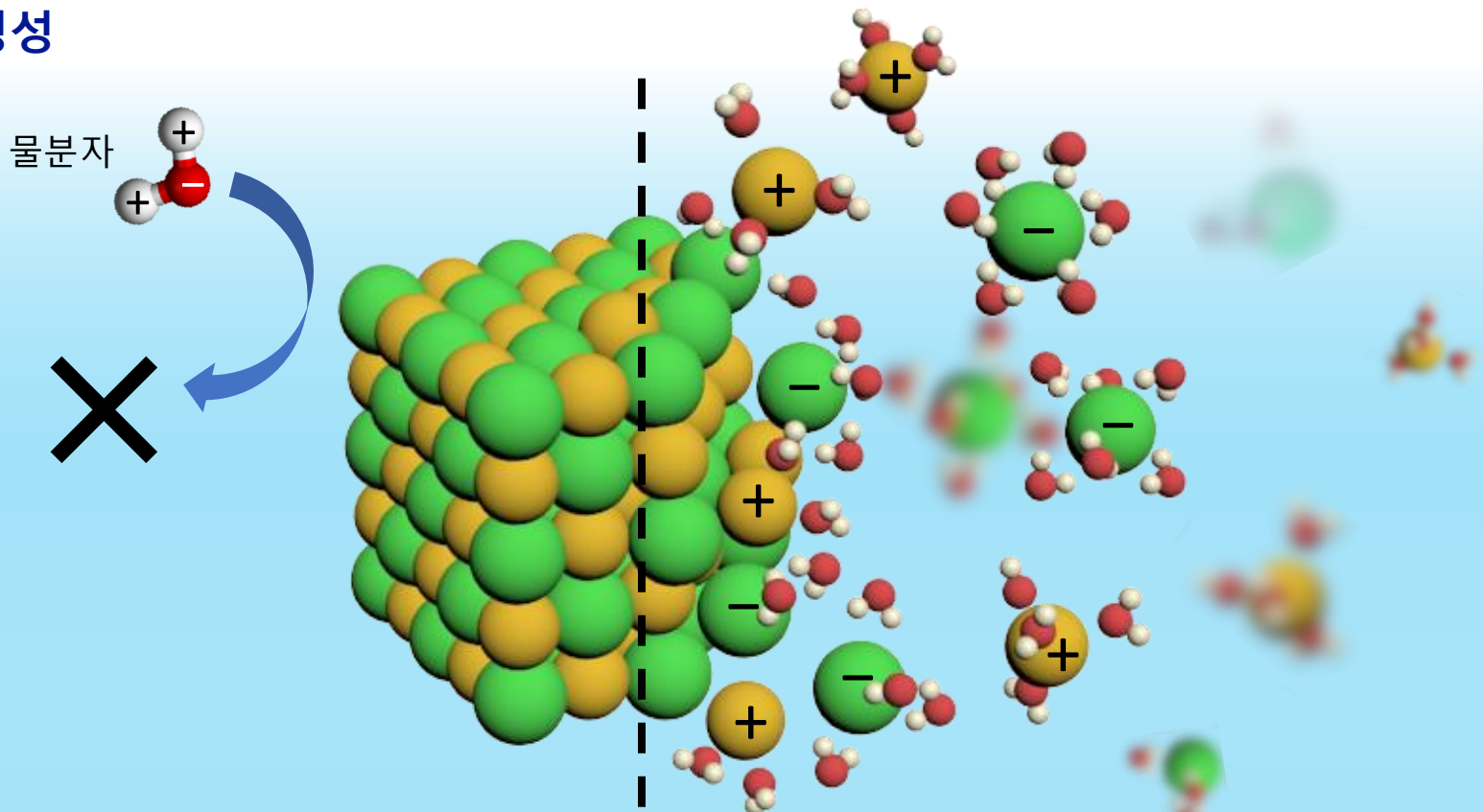
Improved Performance through Ligand-dependent Energy Level



Quantum Dots with Covalent Crystal



화학적 안정성

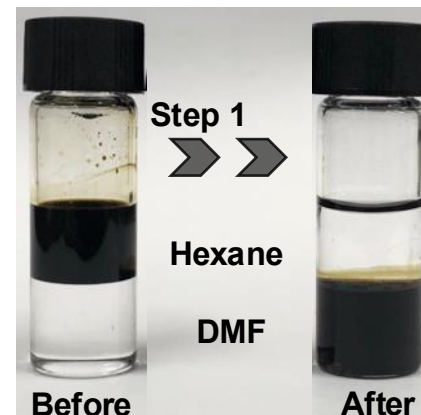
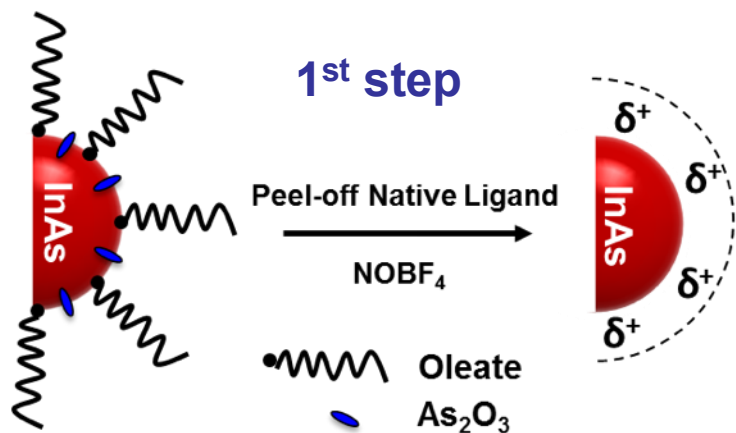


다양한 화학적 스트레스에 안정함
안정한 저독성 소재 ←

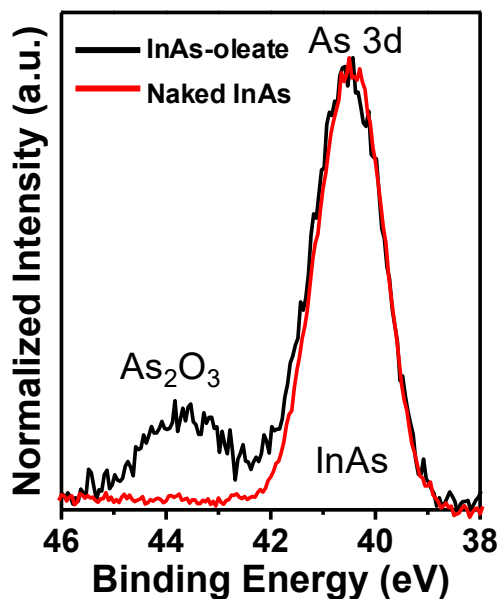
손쉬운 표면 제어와 용해
→ 안정성 및 생체 독성 문제

Surface Modifications of Covalent Crystal QDs

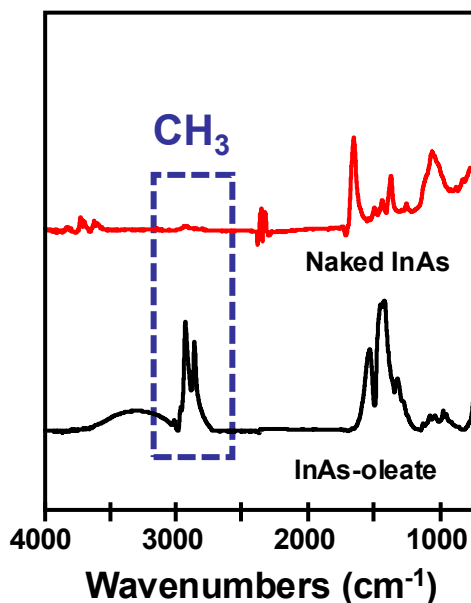
2단계 표면개질 (Two step surface modification) 기술 개발



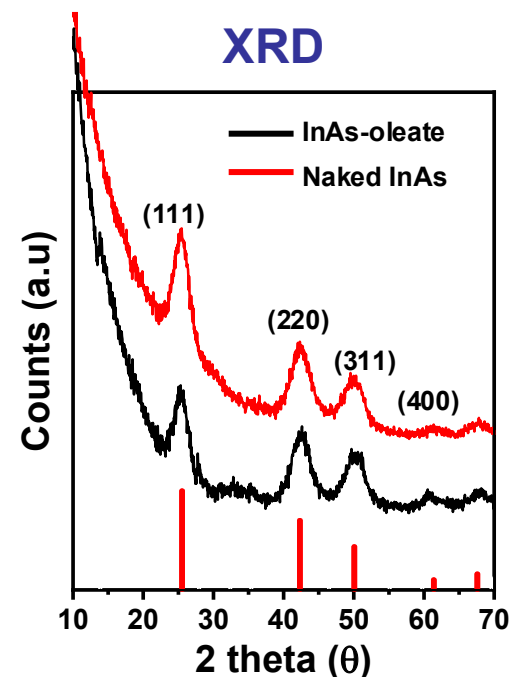
XPS



FT-IR

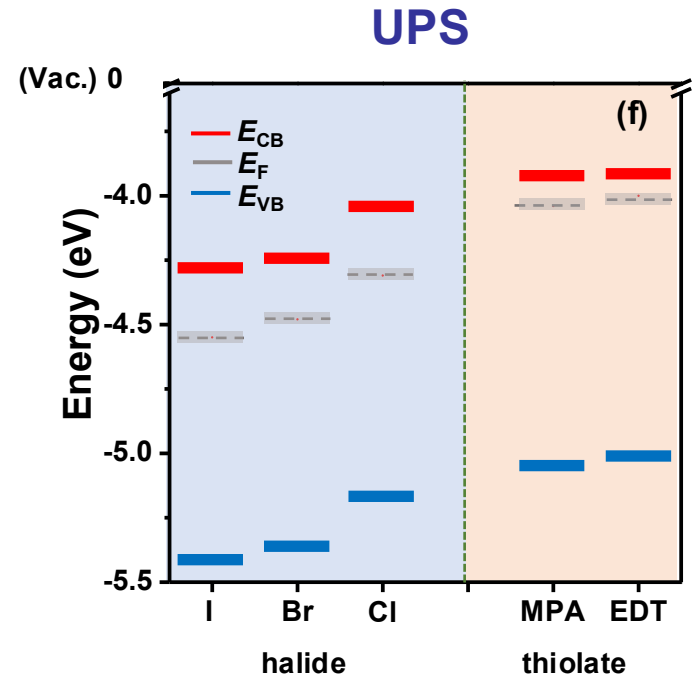
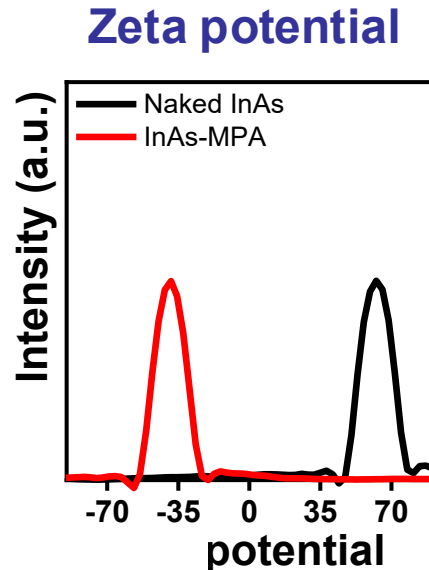
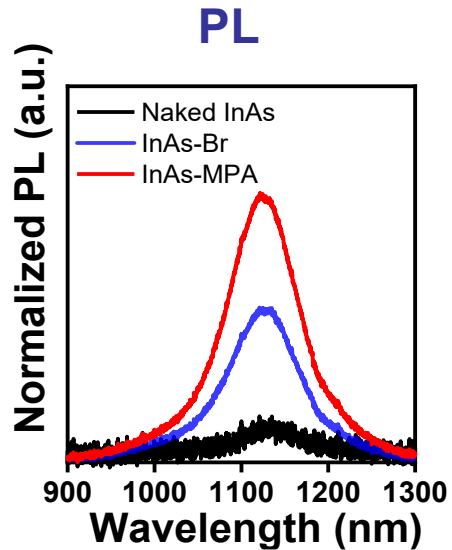
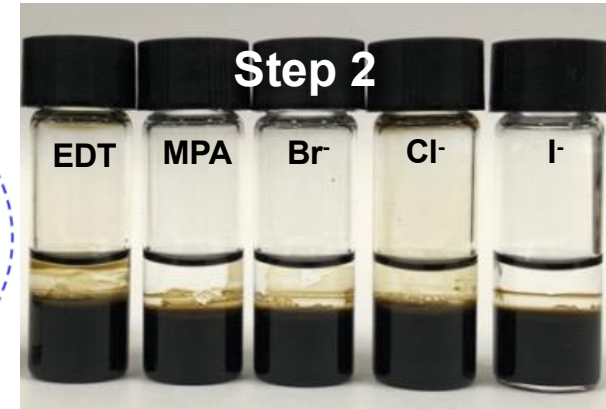
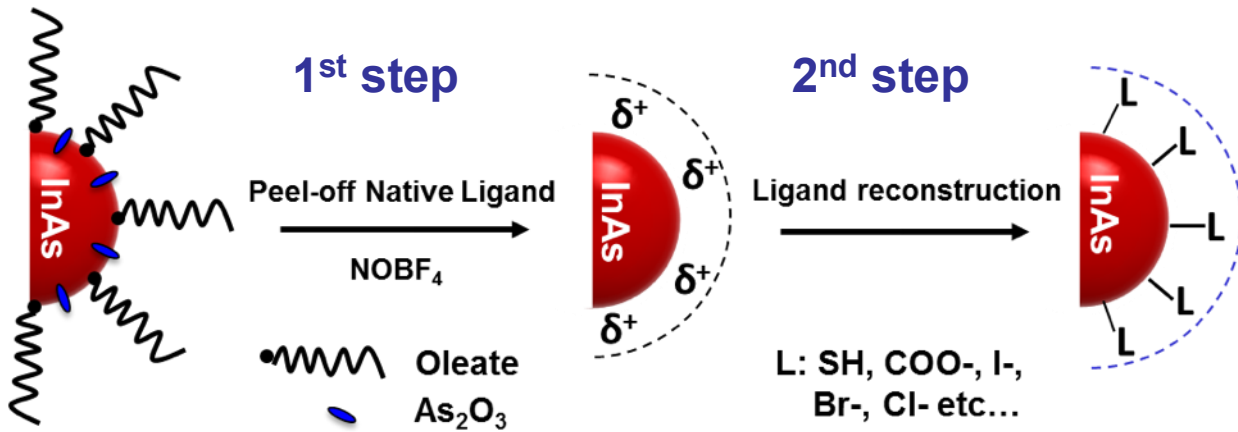


XRD



Surface Modifications of Covalent Crystal QDs

2단계 표면개질 (Two step surface modification) 기술 개발



Fabrication of Solar Cells using Covalent Crystal QD

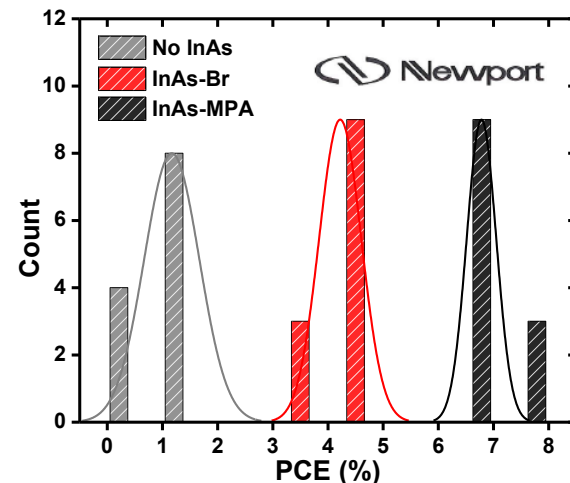
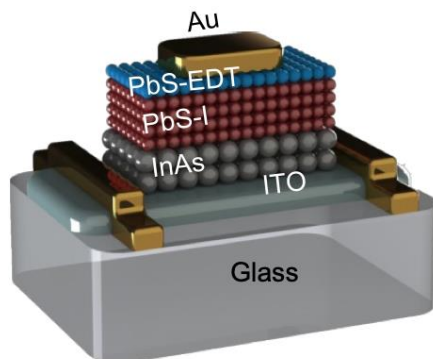
Analysis of physical properties of covalent crystal QDs

Materials	Mobility ($\text{cm}^2 \text{V}^{-1} \text{s}^{-1}$)	Carrier Concentration (cm^{-3})	Trap Density (cm^{-3})	Diffusion Length (nm)
InAs-Br	1.55×10^{-3} (FET) 1.34×10^{-3} (3D PL)	2.77×10^{16} (FET) 4.65×10^{16} (C-V)	3.32×10^{17} (3D PL)	30 (3D PL)
InAs-MPA	2.25×10^{-3} (FET) 1.78×10^{-3} (3D PL)	1.28×10^{17} (FET) 1.27×10^{17} (C-V)	1.24×10^{17} (3D PL)	60 (3D PL)

Device for Covalent Crystal QD Applications

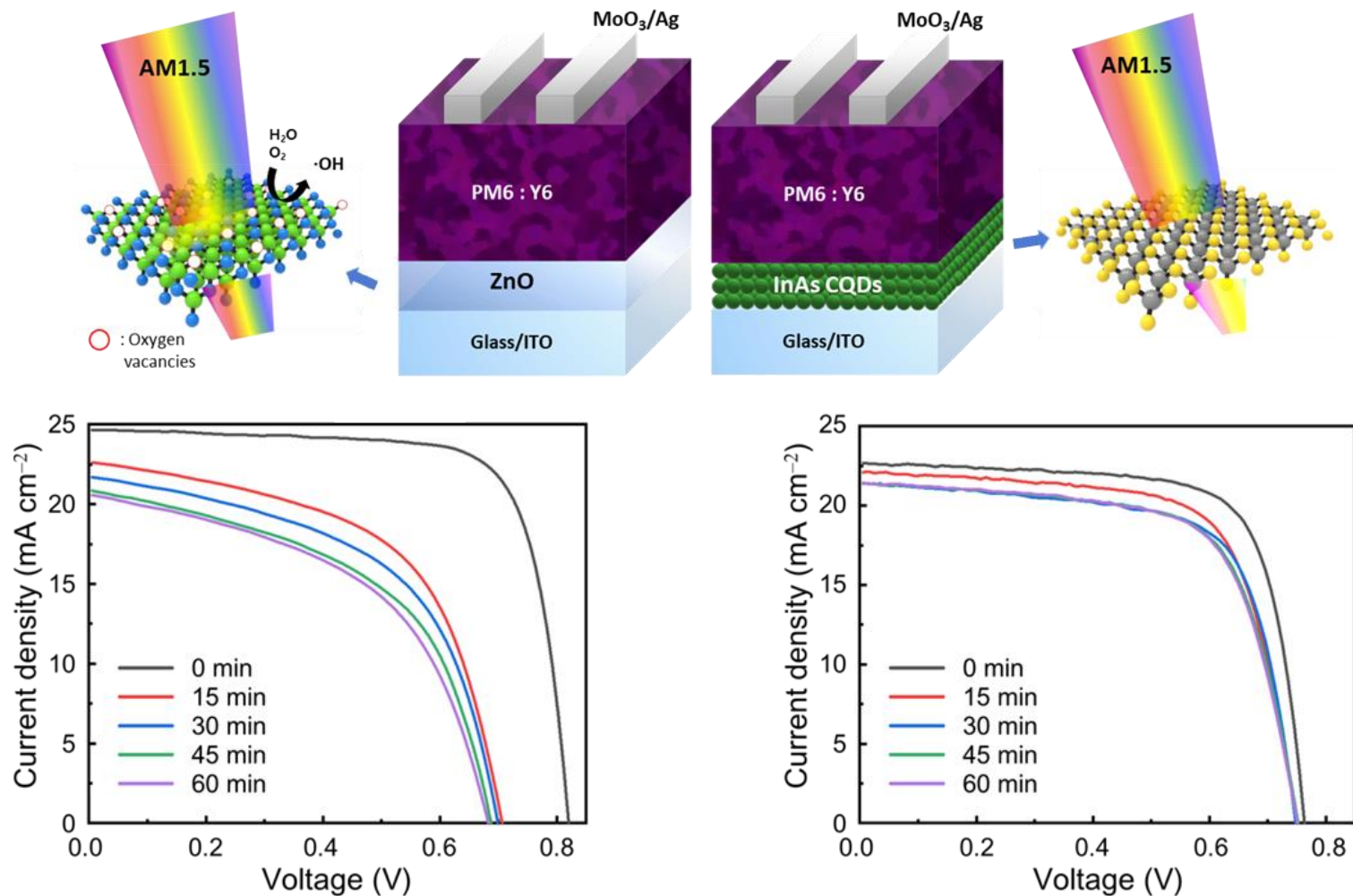
Key Issue:

- High doping concentration
- Only n-type doping polarity
- Short diffusion length

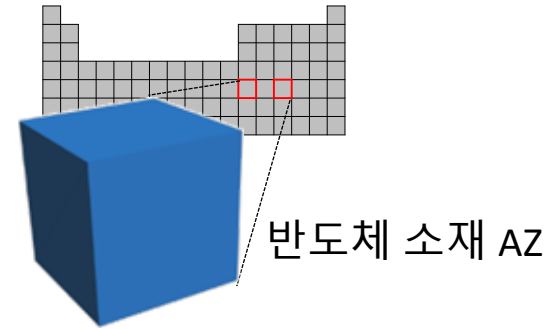


Fabrication of Solar Cells using Covalent Crystal QD

Charge-Selective, Narrow-Gap InAs QD for Highly Stable and Efficient Organic Photovoltaics

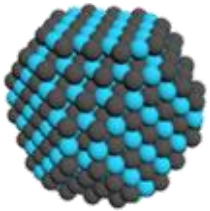


Conclusion



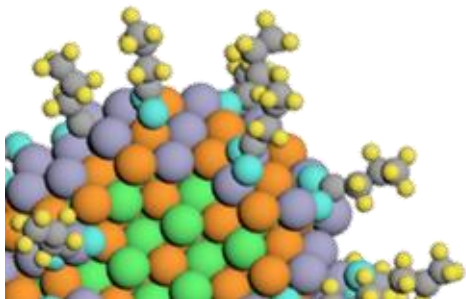
반도체 소재 AZ

양자점 합성
소재의 저차원화

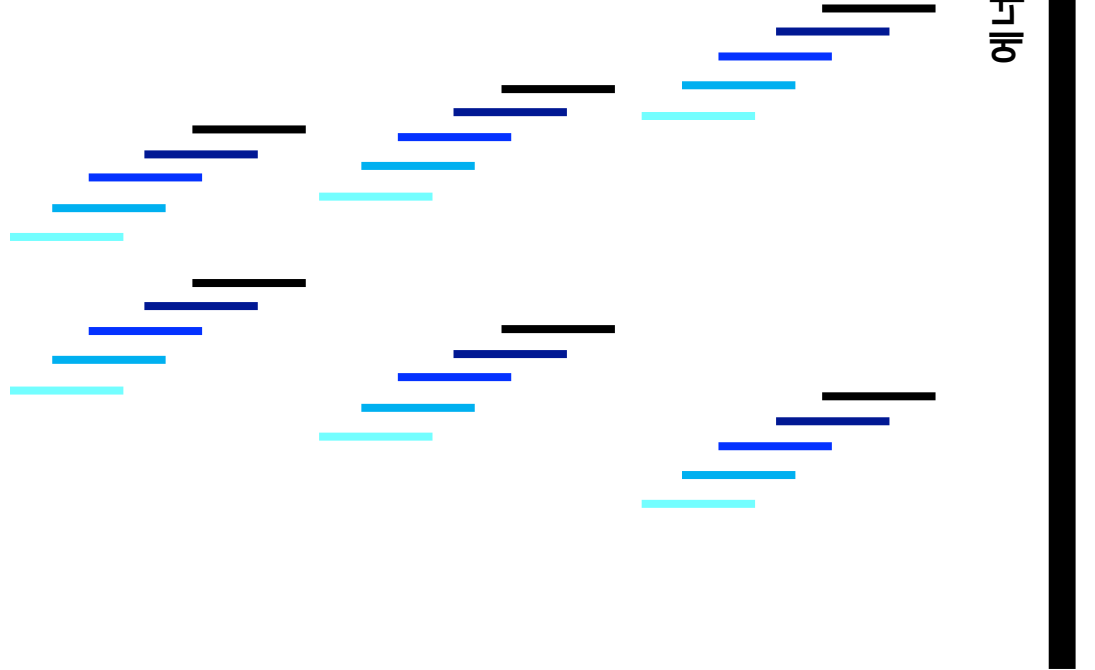


양자점 소재

표면 개질
최외각 껍질층 제어



전범위에 걸친 전자준위의 자유로운 조절:
전자의 형성, 천이, 분리, 이동을 자유자재로 제어



양자점 소재의 전자 구조 연속 제어

→ 양자점 합성과 표면개질의 조합을 통해 자유로운 물성 제어 가능 → 전자소재의 특성 극대화

Acknowledgement



Keit

한국산업기술평가관리원

시장 주도형 K-센서기술개발
(저가형 eye-safe 대역 SWIR 센서)

OLED 한계 돌파형 사용화 제품을
위한 기술개발
(QD-OLED 시장 확대를 위한 광변
환층용 고효율/고신뢰성 양자점재
료 개발)

SAMSUNG

삼성디스플레이

Post-InP QD 개발

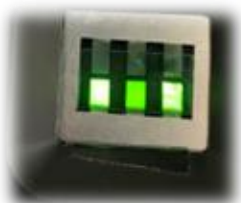
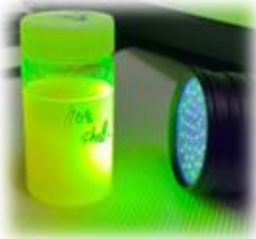
소자제작
(용액공정)

양자점 합성

소자제작 (전극 및 박막제작)



LED



PD, PV

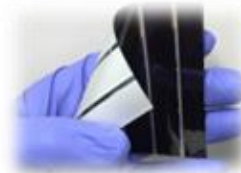
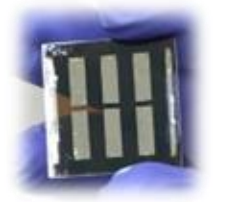
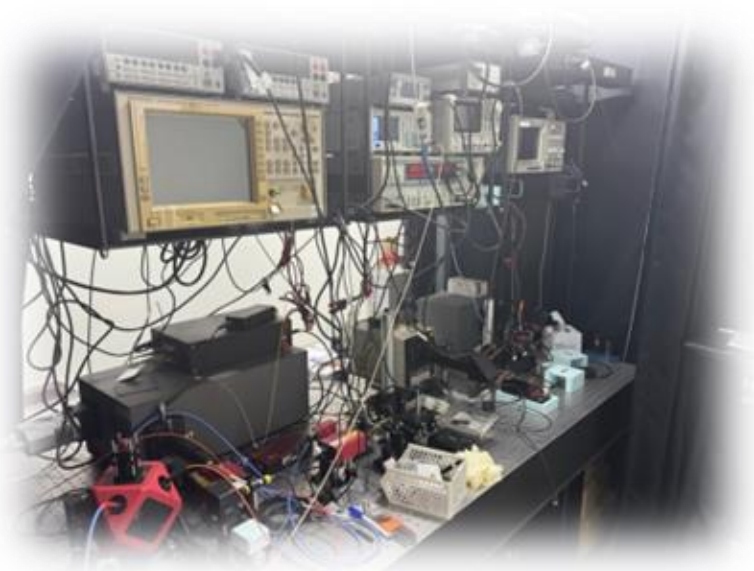


Photo & E-beam Lithography



양자점 소재 특성 분석



양자점 소자 특성 분석



양자점 소재 분석 종류

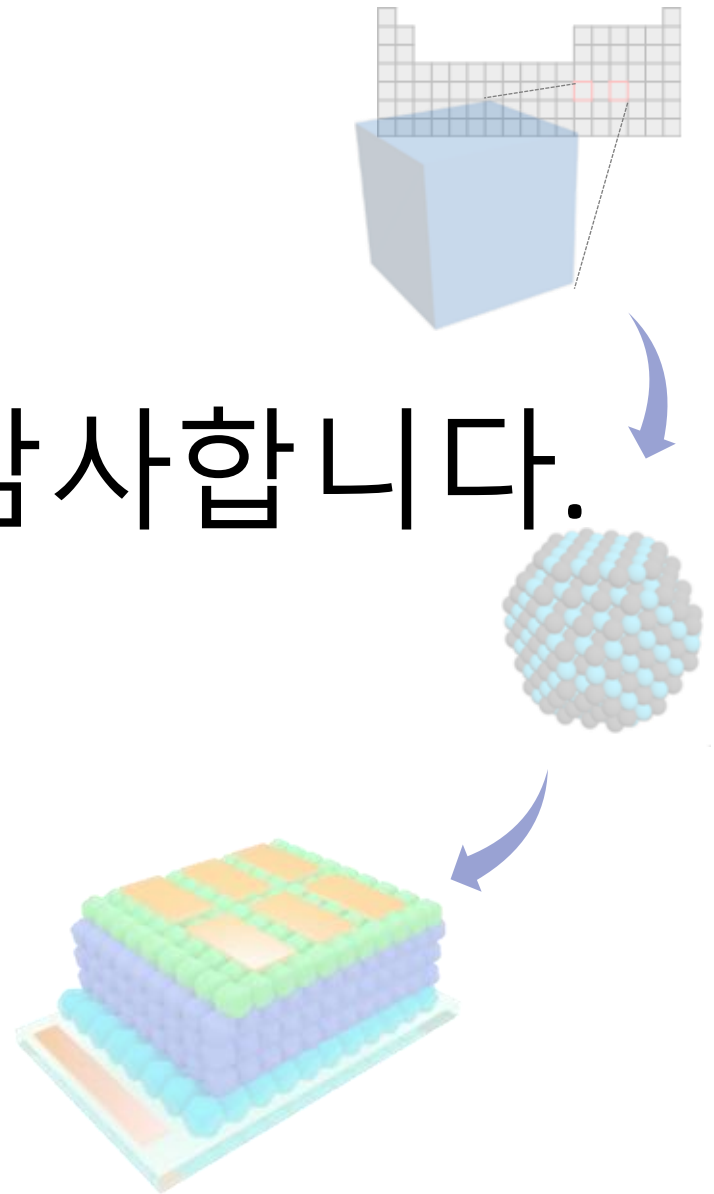
- 흡광 & 발광 분석

405nm, 450nm, 630nm, 1550nm 레이저

양자점 소자 분석 종류

- IV 특성 분석
- Solar cell: PCE 분석
- LED: L-I-V 특성 분석
- ToF 분석
- Photo CELIV 분석
- EQE & Resonsivity 분석
- C-V 특성 분석

경청해 주셔서 감사합니다.



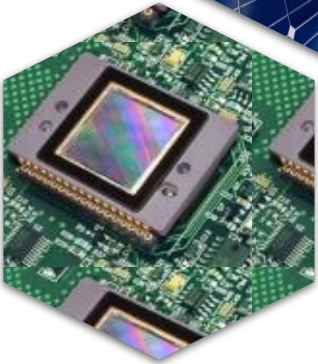
Conclusion



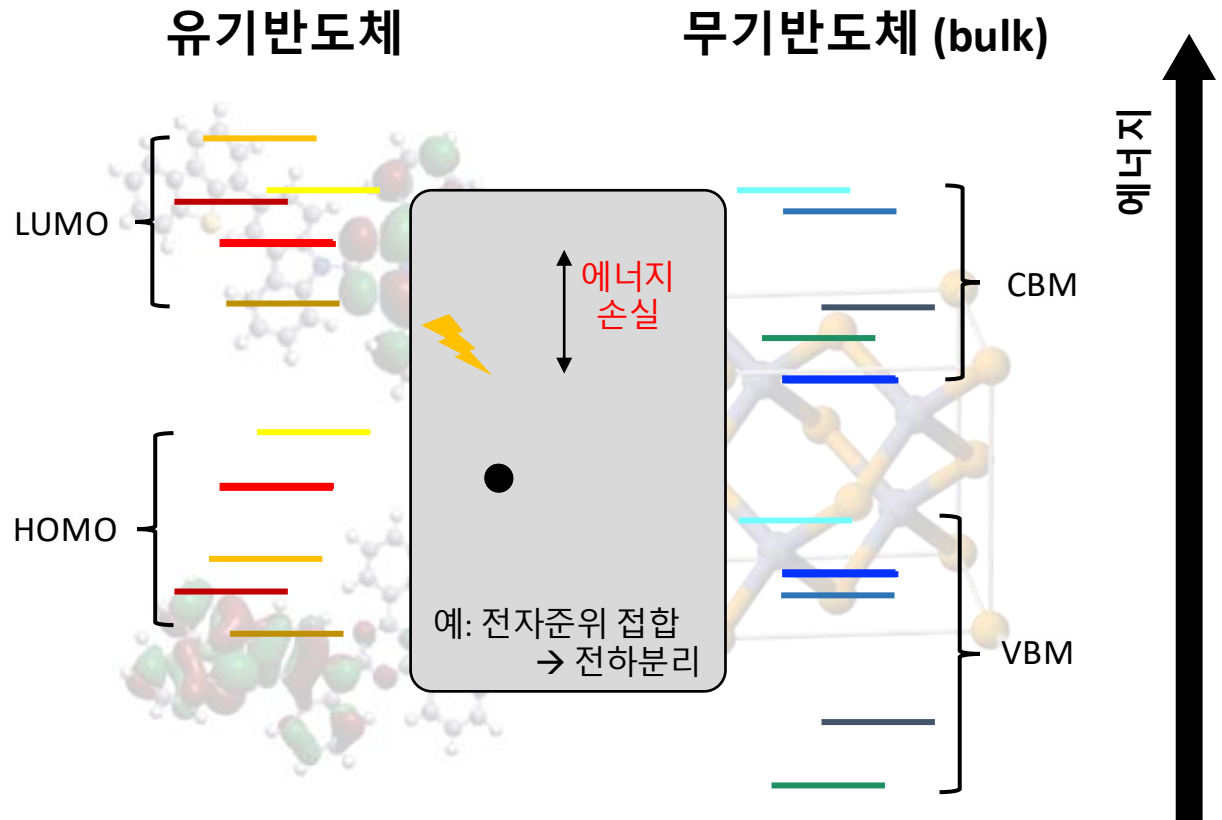
발광소자



태양전지



검출소자



반도체는 현대 전자부품의 핵심 소재

- 다양한 전자준위의 조합을 통한 광/전기/화학적 특성 발현
- 전하의 이동에서 전자준위의 차이는 에너지의 손실로 이어짐

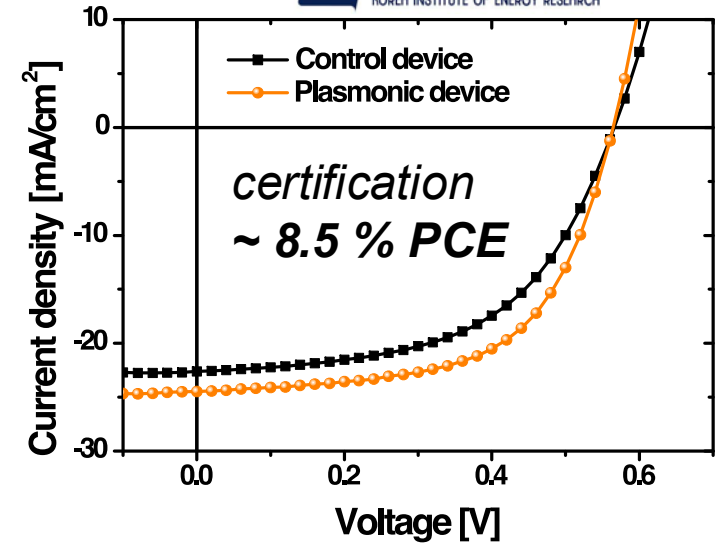
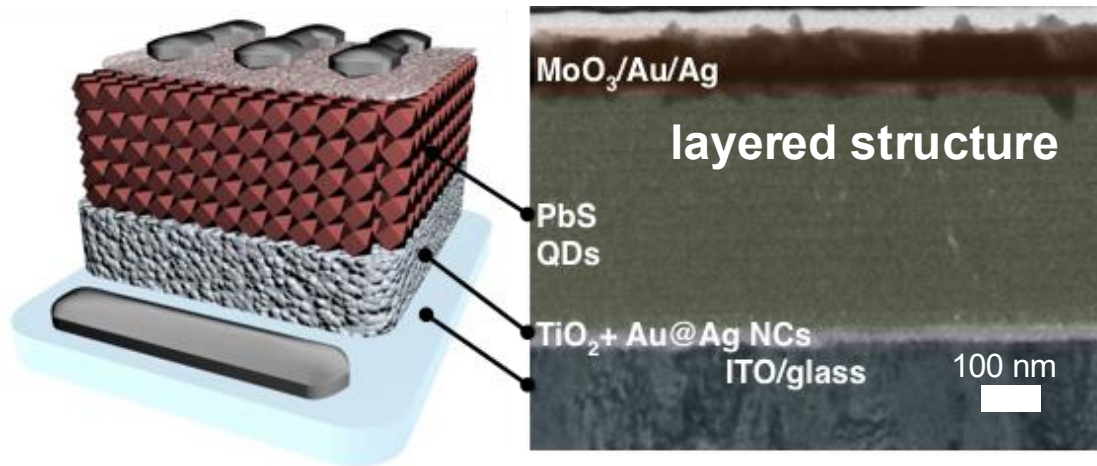
→ 표면 개질을 이용한 전자준위의 연속적인 제어

Properties Depending on Surface Modification

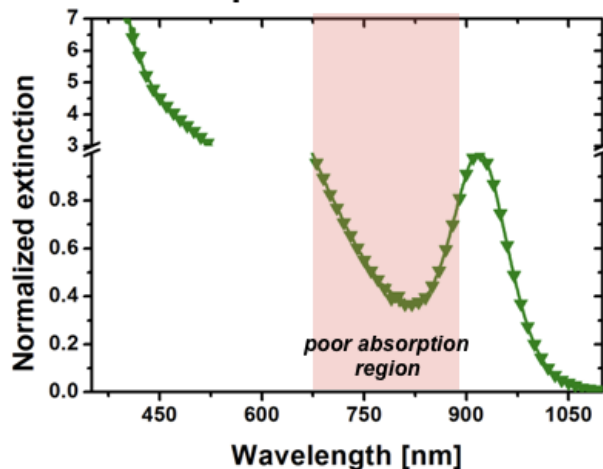
CQD Solar Cell using LBL Process

J. H. Song, et al., *Adv. Mater.*, 2015, 27, 8102

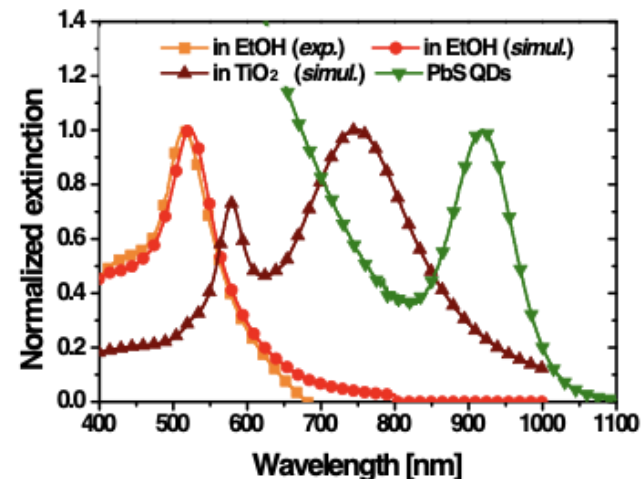
KIER 한국에너지기술연구원
KOREA INSTITUTE OF ENERGY RESEARCH



External quantum efficiency & absorption in solar cells



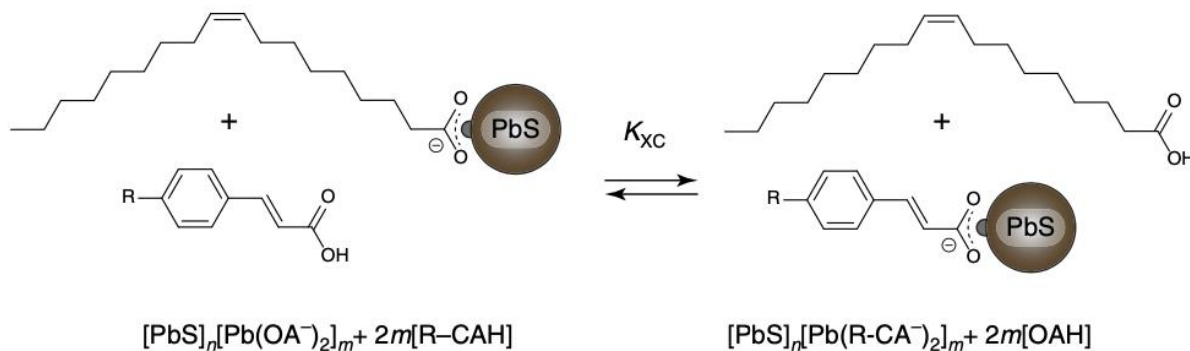
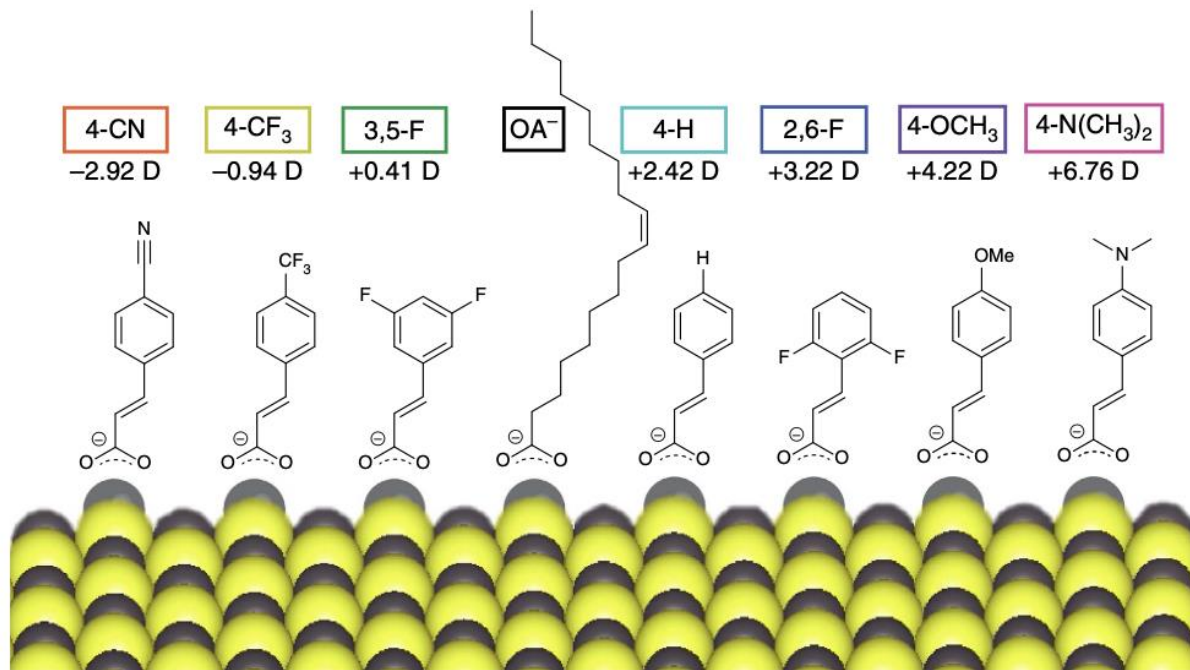
NCs scattering in TiO₂ & QD abs.



Properties Depending on Surface Modification

Ligand-dependent Energy Level

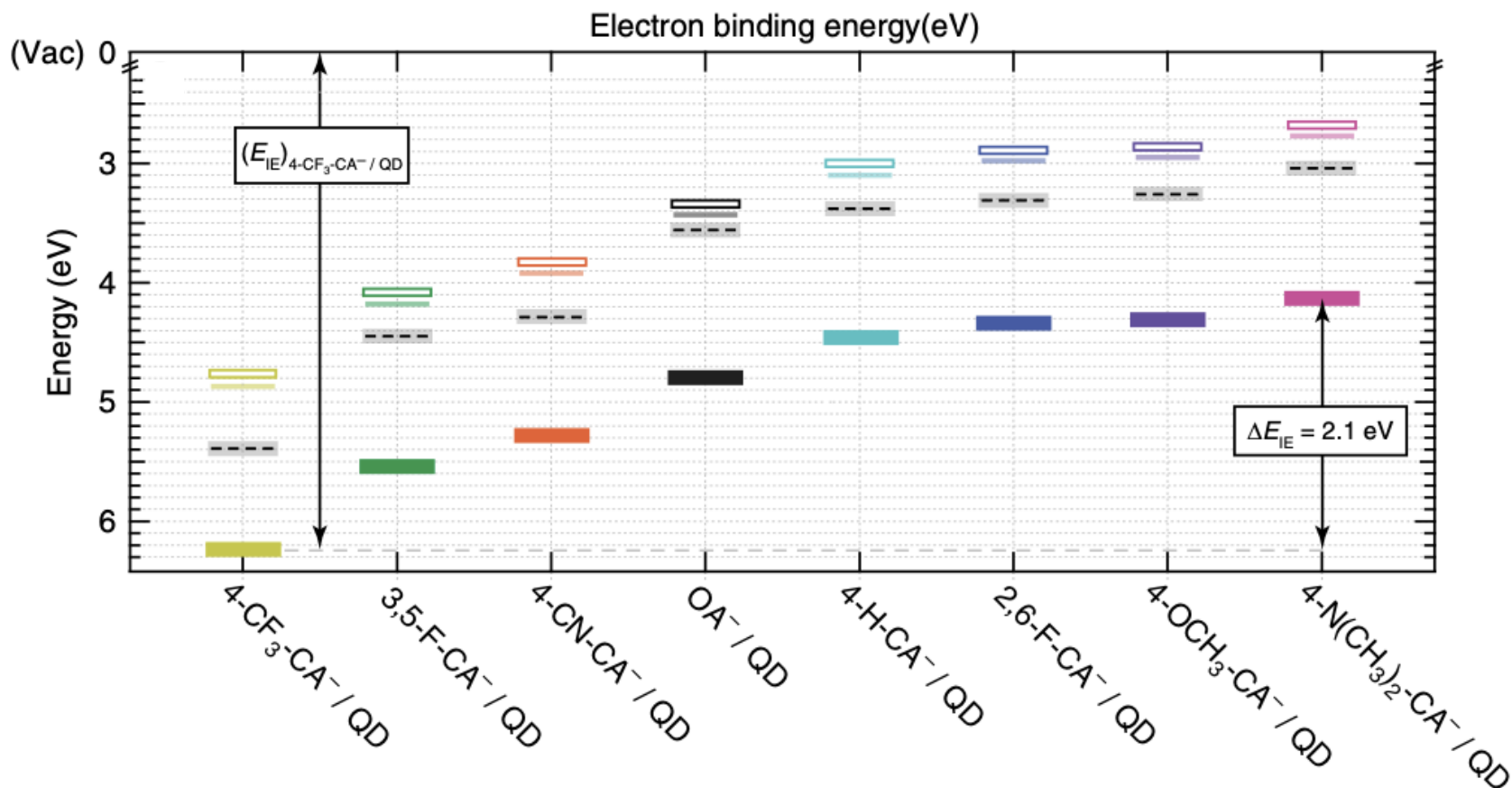
D. M. Kroupa et al., Nat. Commun., 2017, 8, 15257



Properties Depending on Surface Modification

Ligand-dependent Energy Level

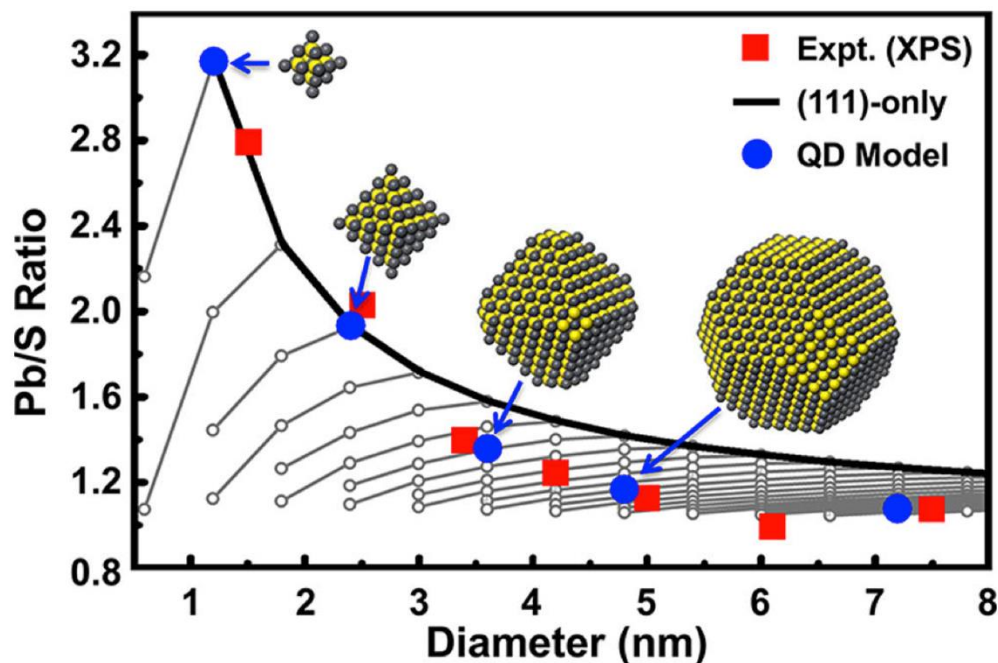
D. M. Kroupa et al., Nat. Commun., 2017, 8, 15257



Properties Depending on Surface Modification

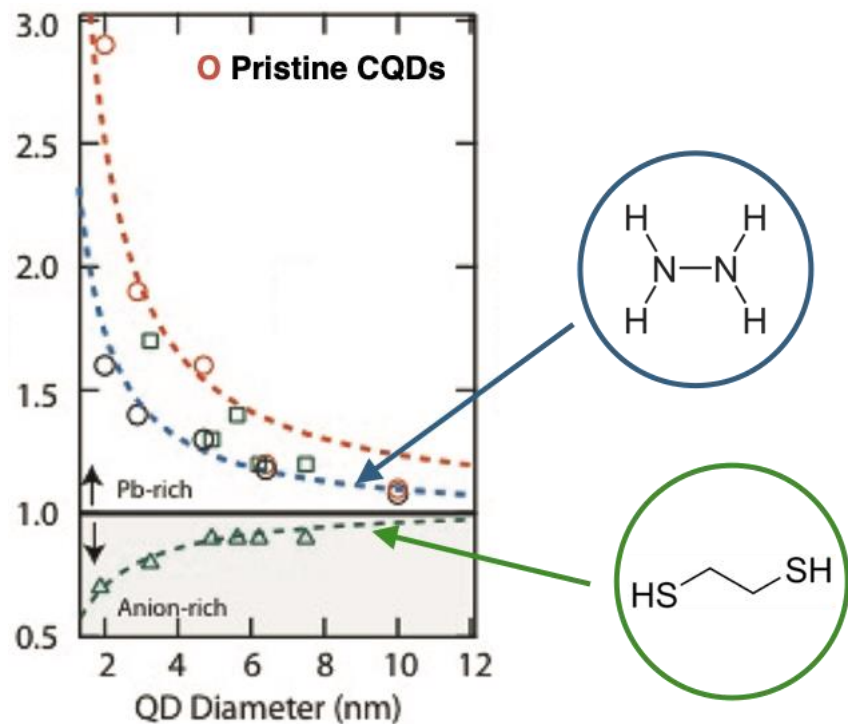
Intrinsic non-stoichiometry

Choi et al. *J. Am. Chem. Soc.* 135, 5278 (2013)

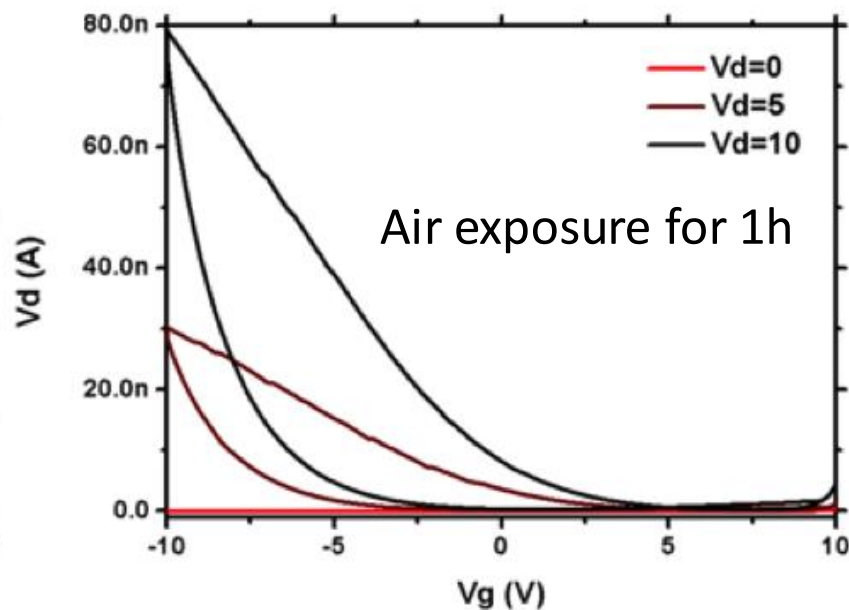
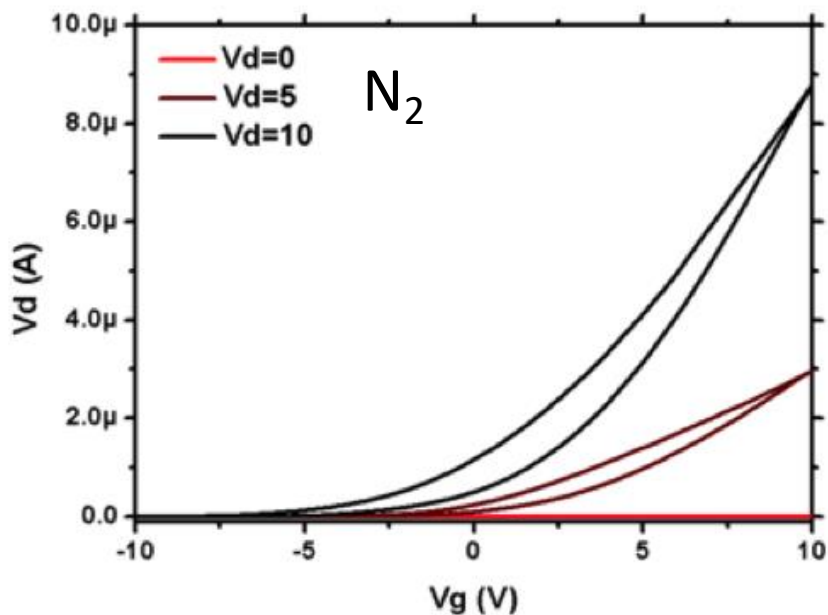
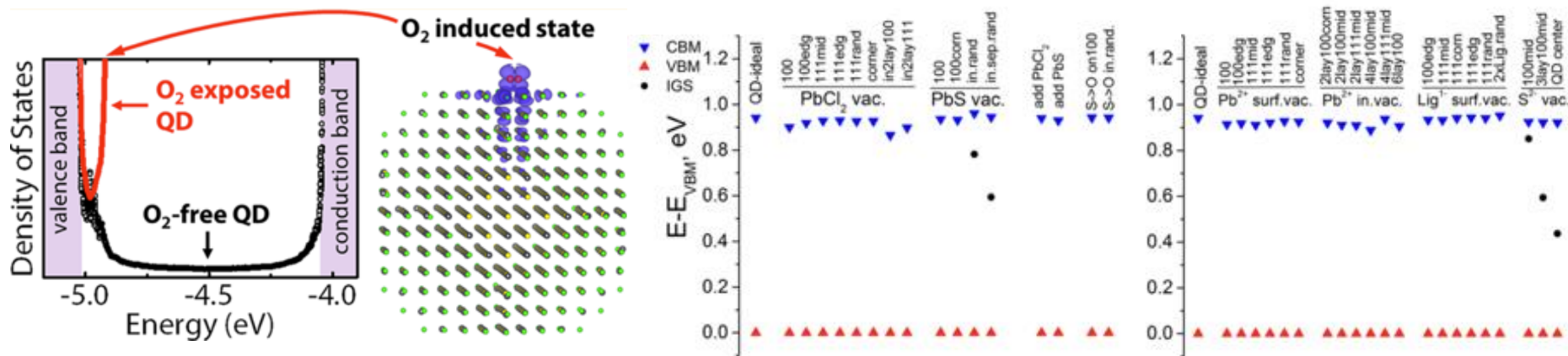


Ligand-induced non-stoichiometry

Hughes et al. *ACS Nano* 6, 5498 (2012)



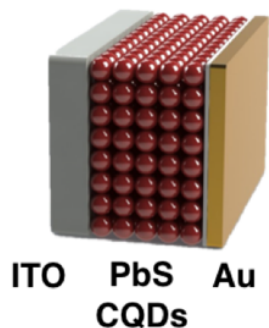
Doping by Physical Adsorption of Oxygen Molecules



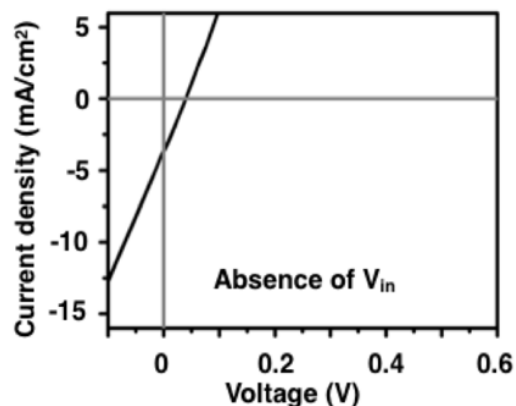
Properties Depending on Surface Modification

Surface modification and induced photovoltaic effect due to external bias

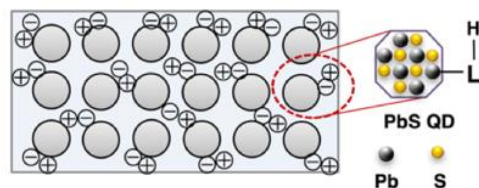
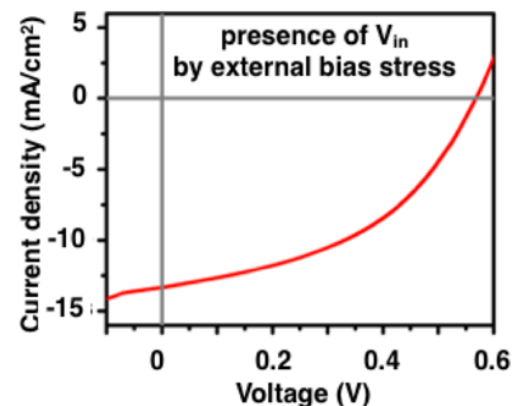
MSM device



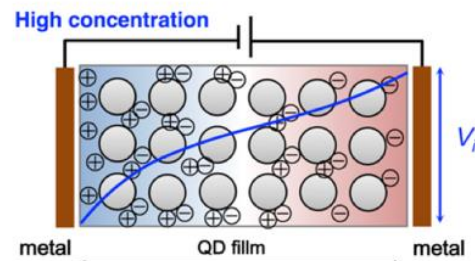
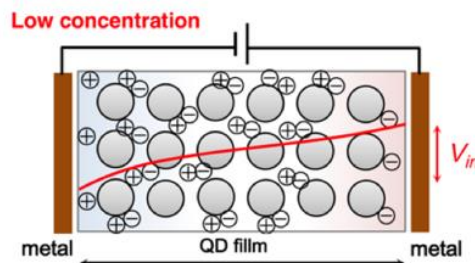
Initial condition



After applying positive bias at Au



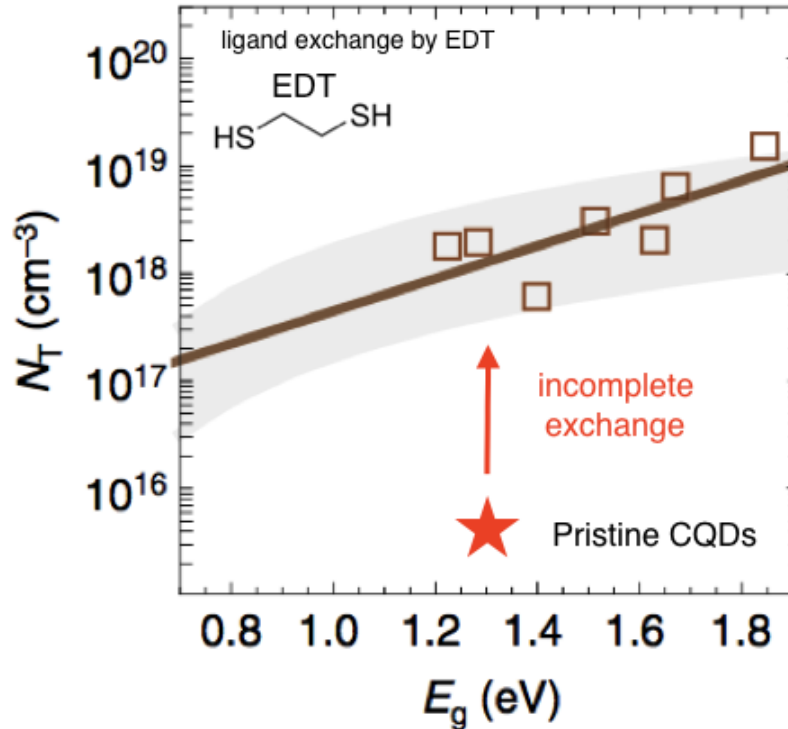
⊕ Cation / proton ⊖ Anion / deprotonated ligand



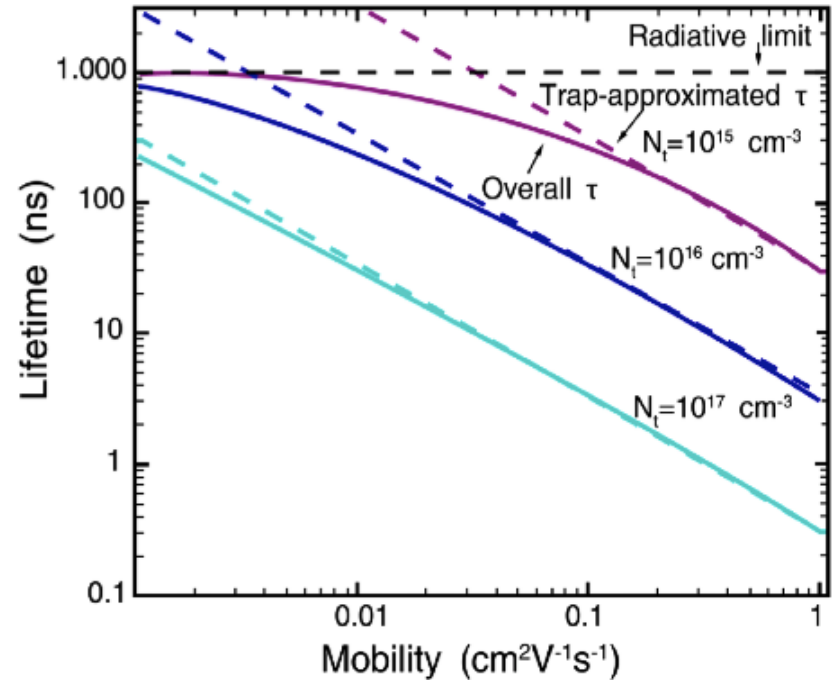
J. H. Song et al., *J. Phys. Chem. Lett.*, 2017, 8, 5259

Defect Concentration Depending on QD Size

Size-dependent trap density



Lifetime and trap density



Zhitomirsky et al. *Nat. Commun.*, 2, 5498 (2014)

Bozyigit et al. *Nat. Commun.* 6, 6180 (2015)

★ Zhitomirsky et al. *ACS Nano* 6, 5282 (2013)

Diffusion Length (L_D)



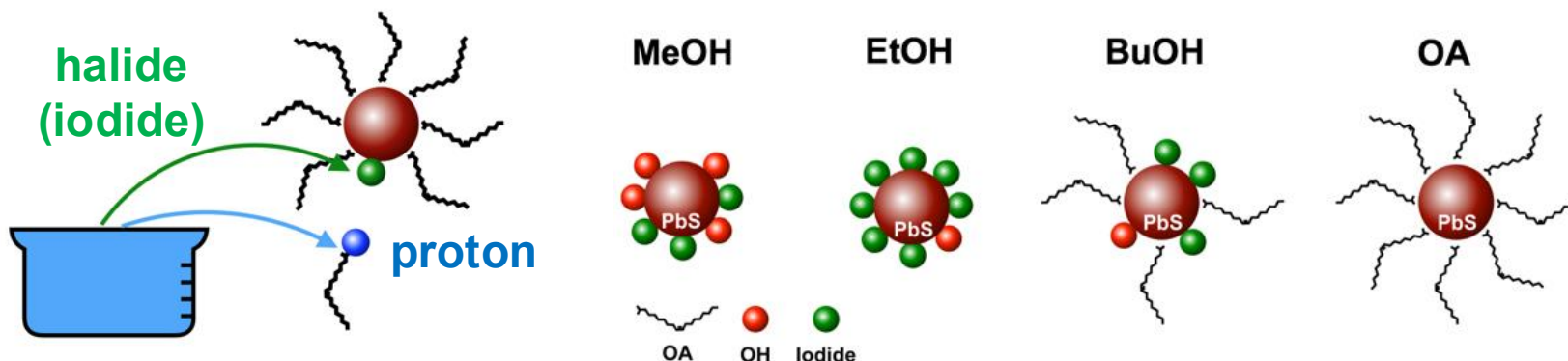
$$\sqrt{\text{Lifetime} \cdot \text{mobility} \cdot \frac{k_B T}{e}}$$

Short diffusion length: low mobility & high trap density

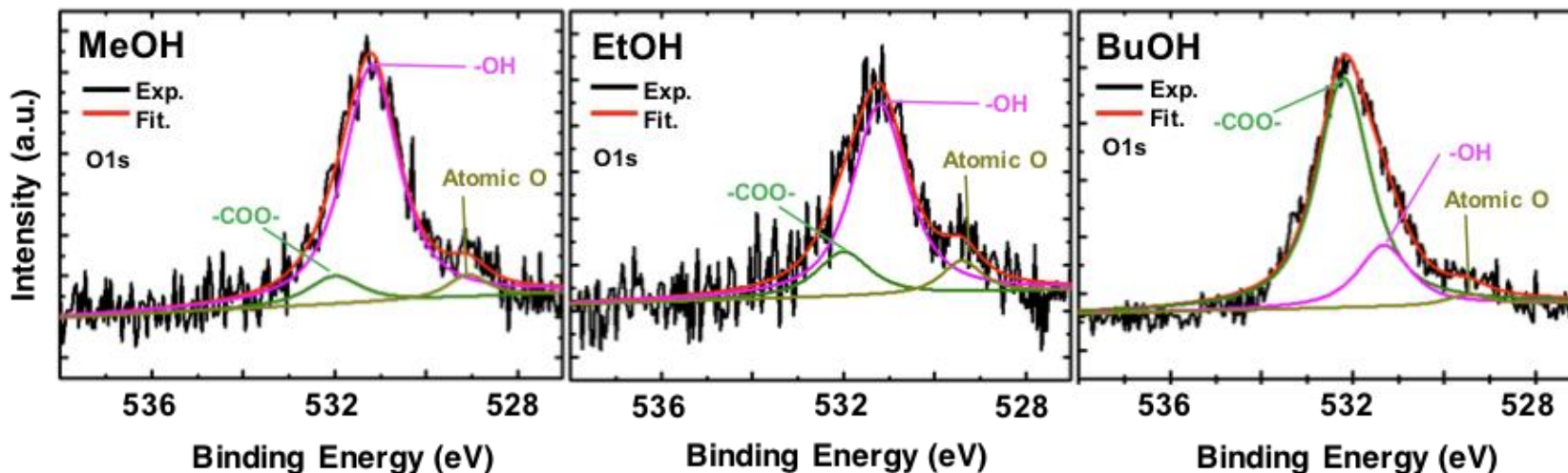
Surface Modifications for Efficient PVs (trap density)

Surface defect control through effective surface ligand exchange
(Diffusion length)

리간드 교환 반응의 원리 규명 및 리간드 교환 반응성 제어



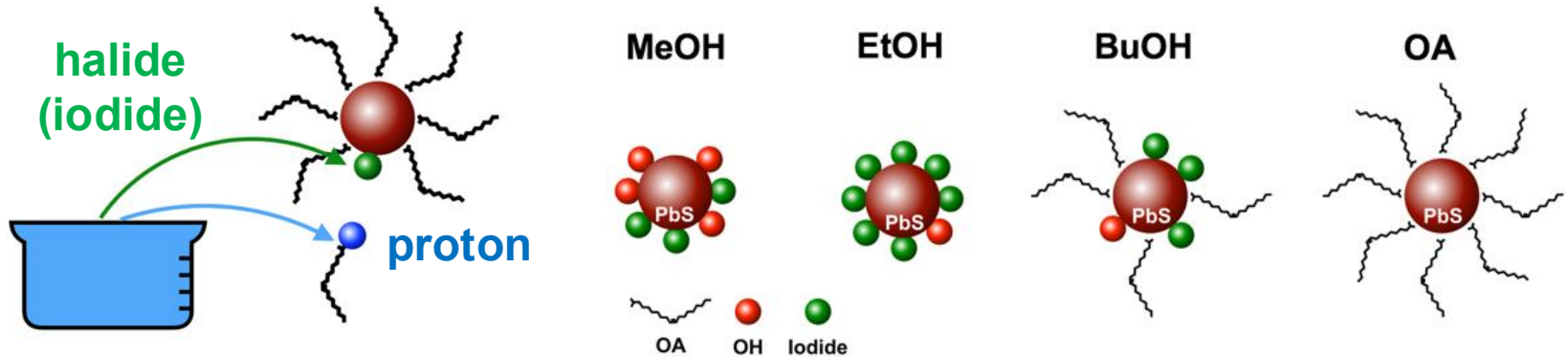
protic solvent (halide salt)



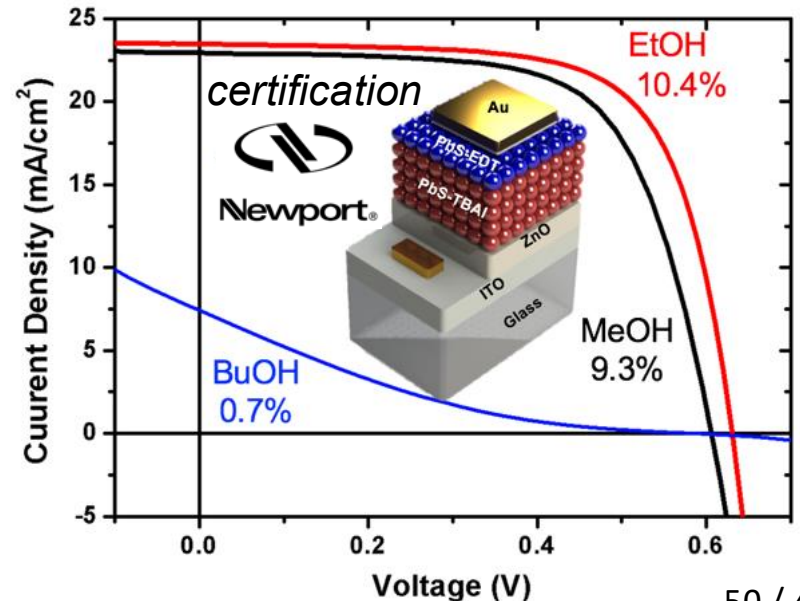
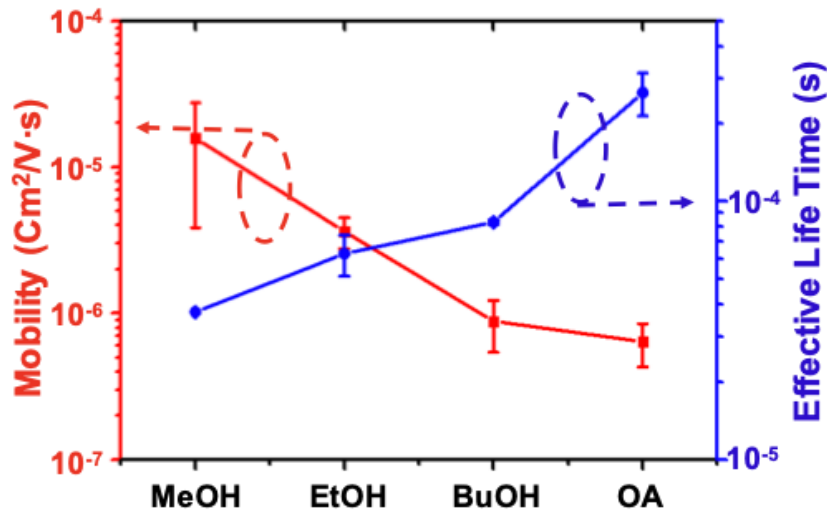
Surface Modifications for Efficient PVs (trap density)

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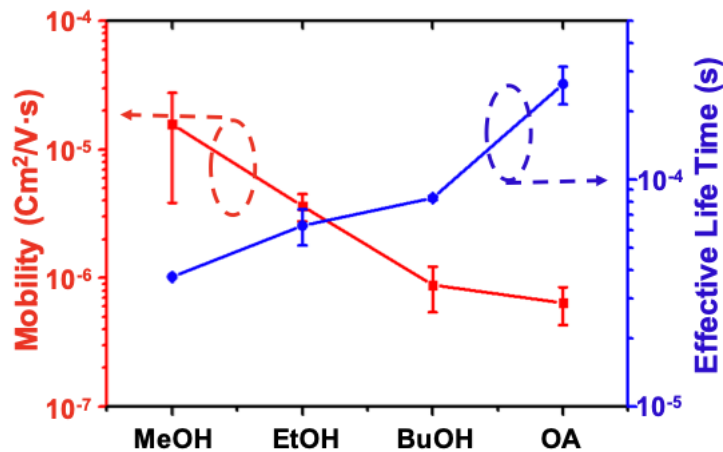
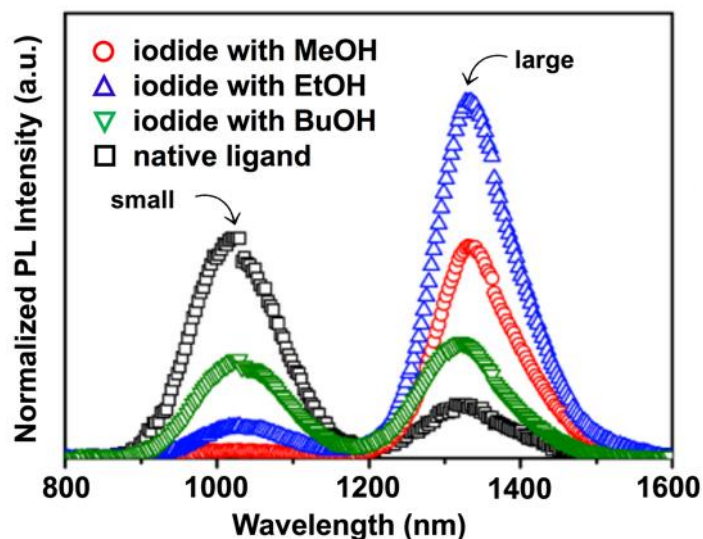
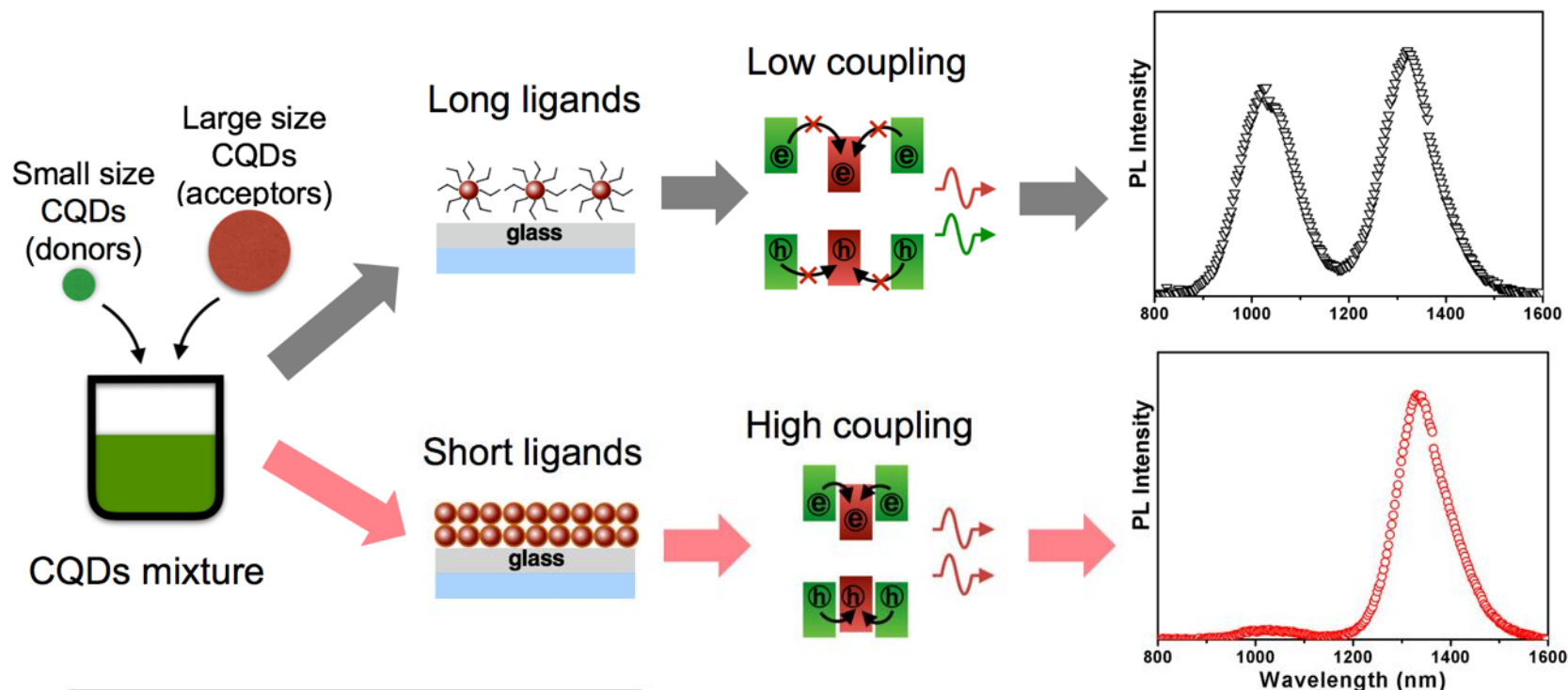
리간드 교환 반응의 원리 규명 및 리간드 교환 반응성 제어



protic solvent (halide salt)



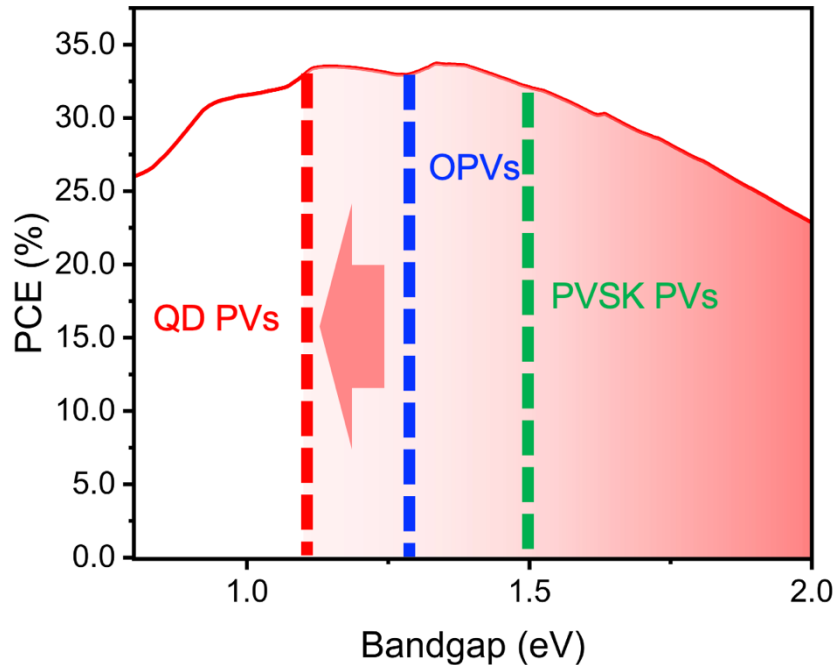
Supplementary Information – 3D PL Measurement



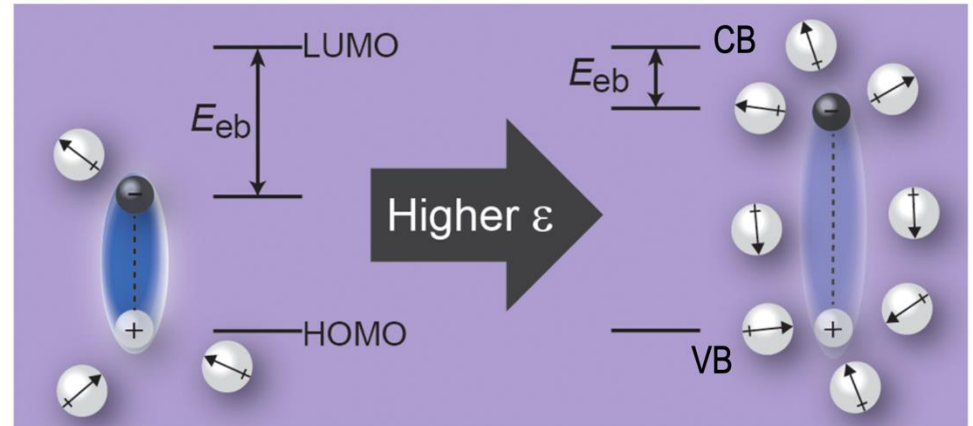
Strategy for High-Efficiency Quantum Dot Solar Cells

Absorption of Long-Wavelength Light

S-Q limit



Quantum Dots with a High Dielectric Constant



- Effective Long-Wavelength Light Absorption
- Thin-film quantum dot solar cells
- Low exciton binding energy
- High refractive index PbS CQDs

Strategy for High-Efficiency Quantum Dot Solar Cells

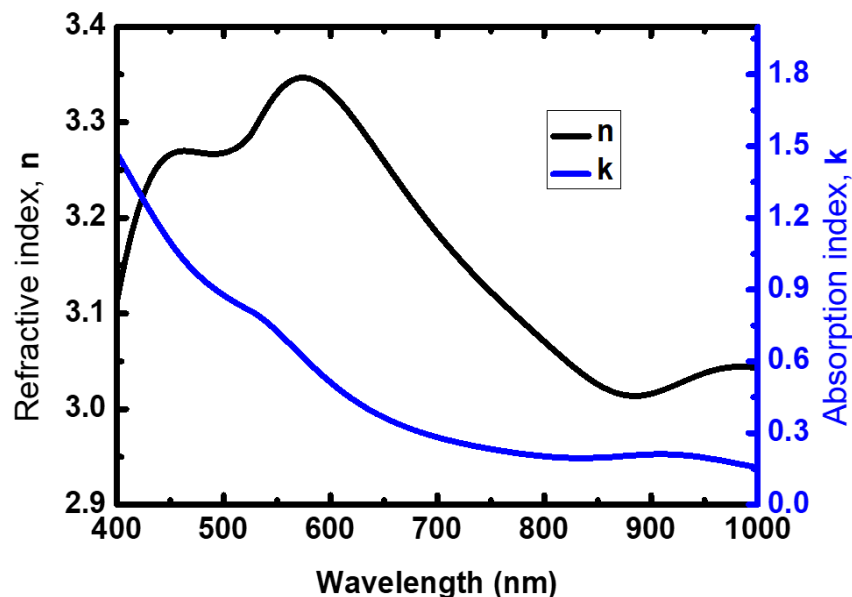
Effective long-wavelength light absorption

→ Thicker active layer

→ Enhanced space charge region through doping control

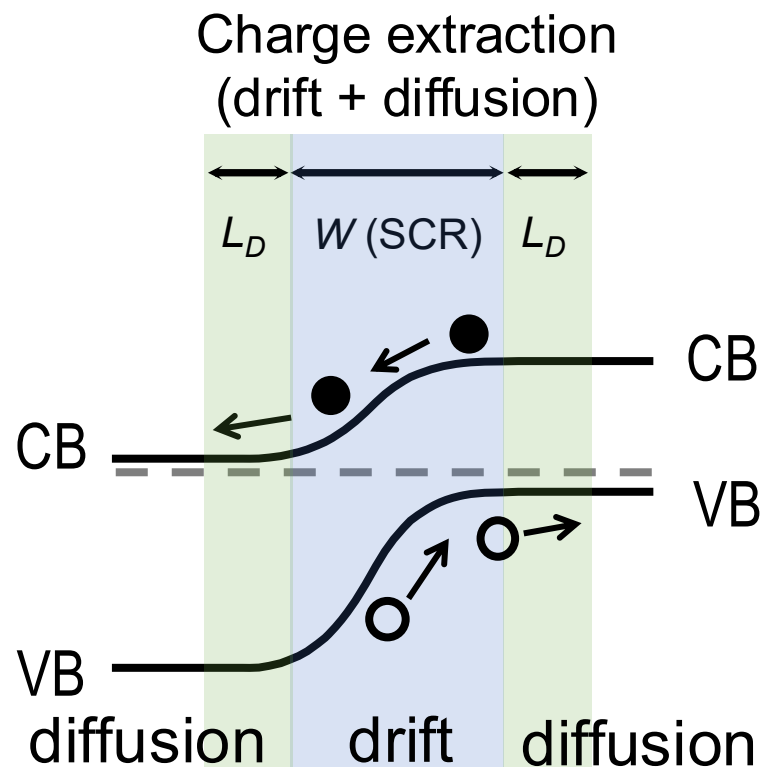
+ Extended diffusion length through improved material quality

PbS quantum dot optical properties



$\epsilon_r \sim 10$ (PbS QDs)

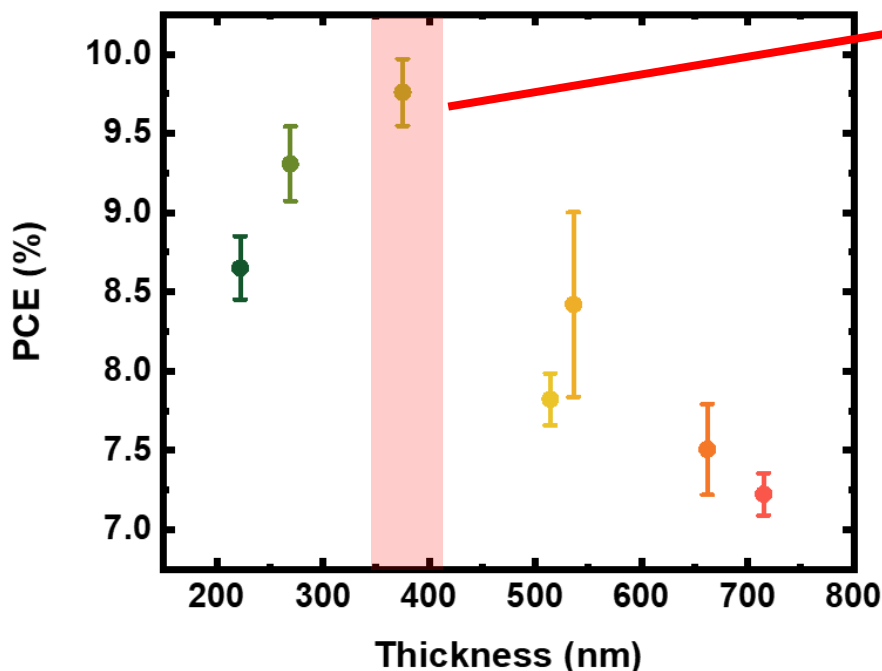
$E_b \sim 25$ meV (PbS QDs)



$$W \sim \sqrt{\frac{2\epsilon\epsilon_0 V_{bi}}{q} \left(\frac{1}{N_a} + \frac{1}{N_d} \right)} \quad L_D \propto \sqrt{\mu\tau}$$

Optimized QD Solar Cell Structure

PCE variation with PbS quantum dot thickness



General optimization process

- **Charge extraction efficiency** **decreases** at thickness near 400nm
- The optimized thickness of the active layer is approximately **400 nm**

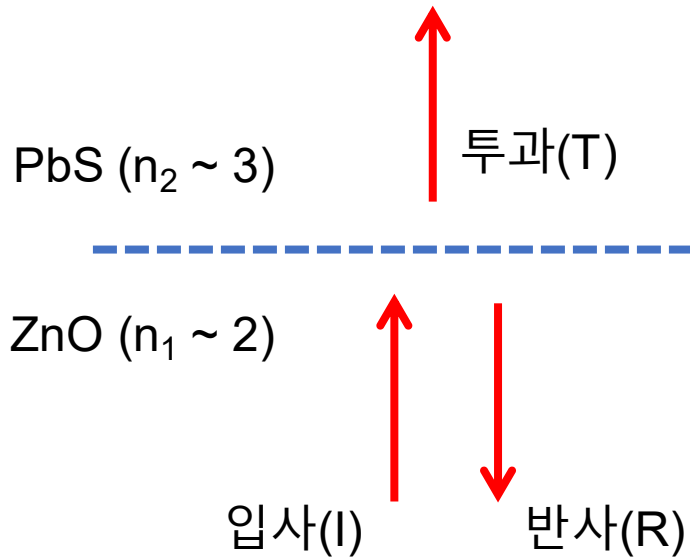


a high refractive index

- Light absorption decreases due to **optical interference**.
- The optimized thickness of the active optical layer can exceed 400 nm

Fresnel reflection and internal reflection

Internal reflection in solar cells
(Fresnel reflection)

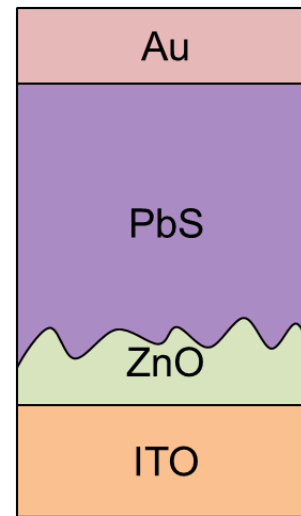


$$R = \left(\frac{n_2 - n_1}{n_2 + n_1} \right)^2$$

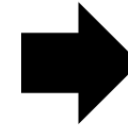
$$R + T = 1$$

Proposed structure to suppress internal reflection

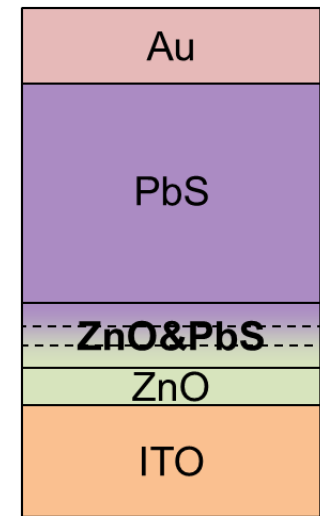
3-D structure



EMA

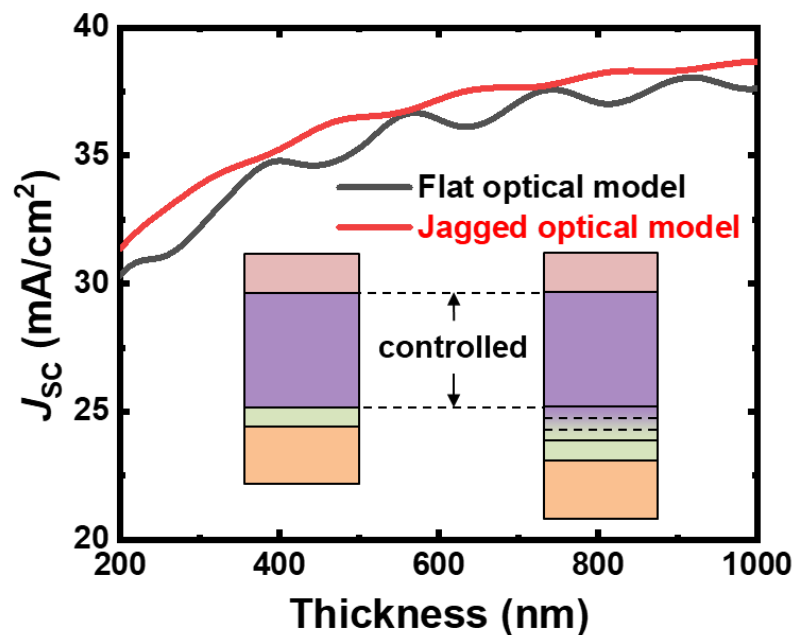


1-D model

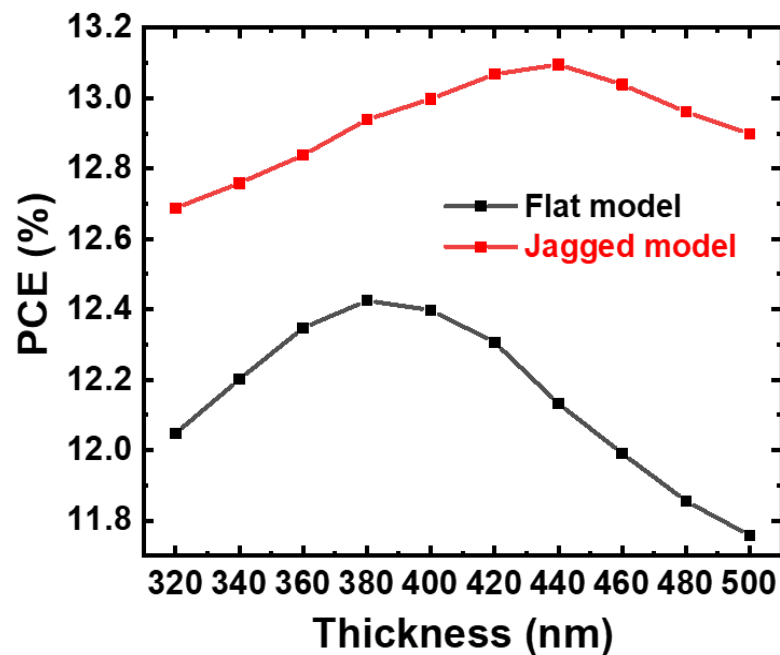


Fresnel reflection and internal reflection

Internal reflection in solar cells
(Fresnel reflection)



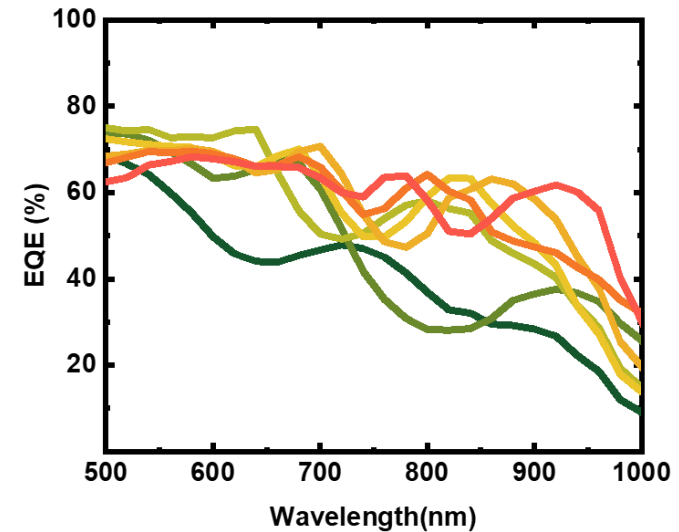
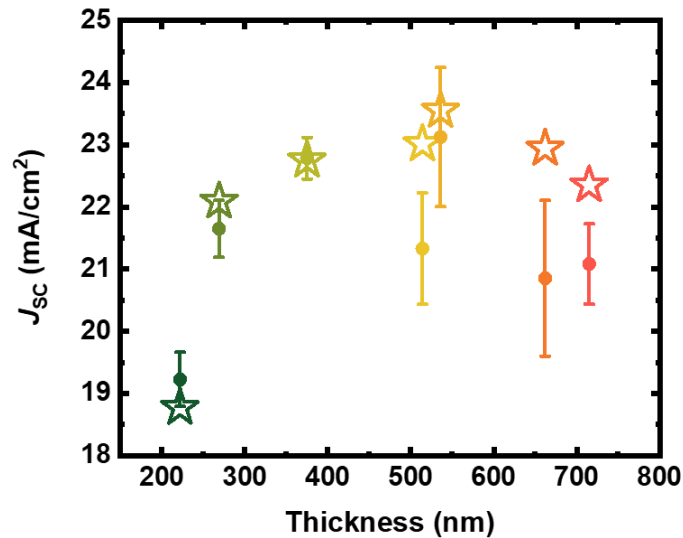
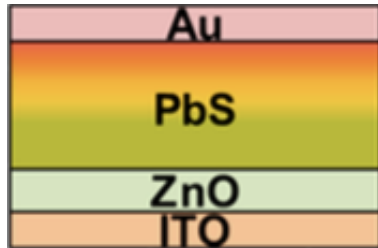
Proposed structure to suppress internal reflection



Effects of optical interference on QD solar cells

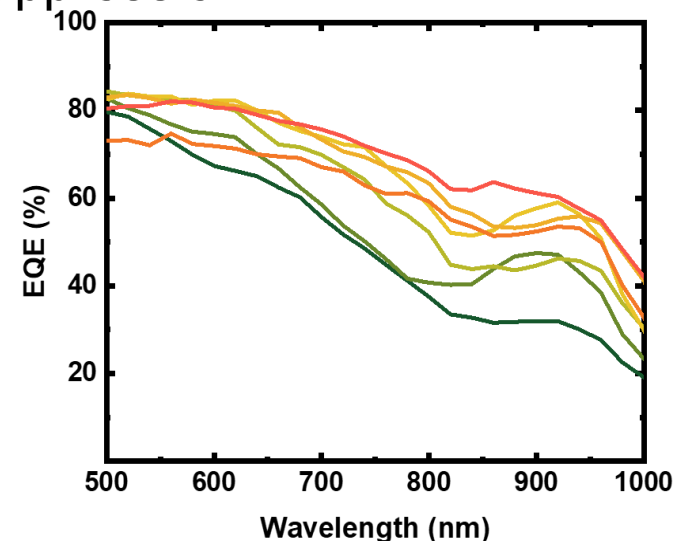
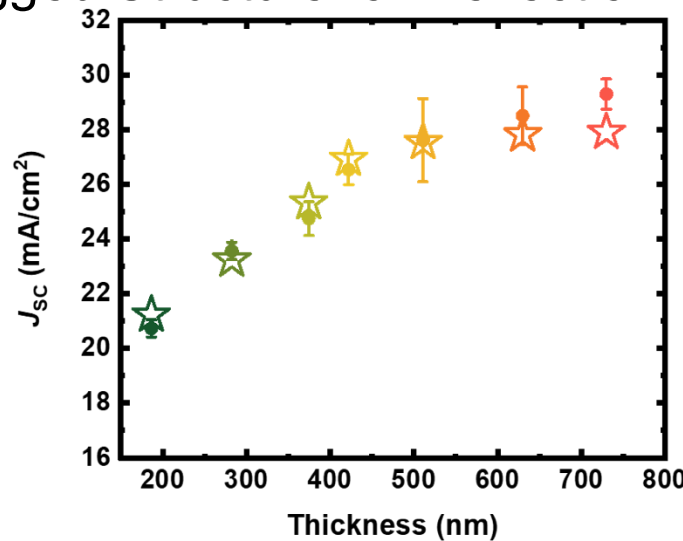
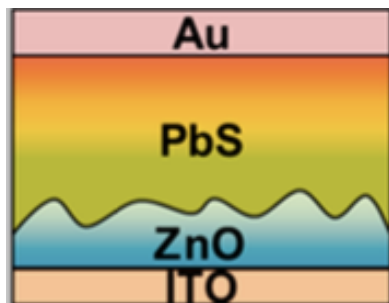
J_{sc} and external quantum efficiency characteristics of a planar device

planar device



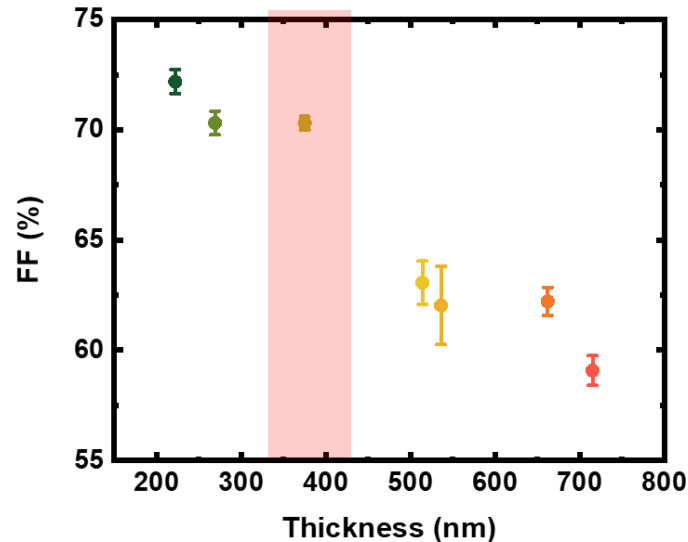
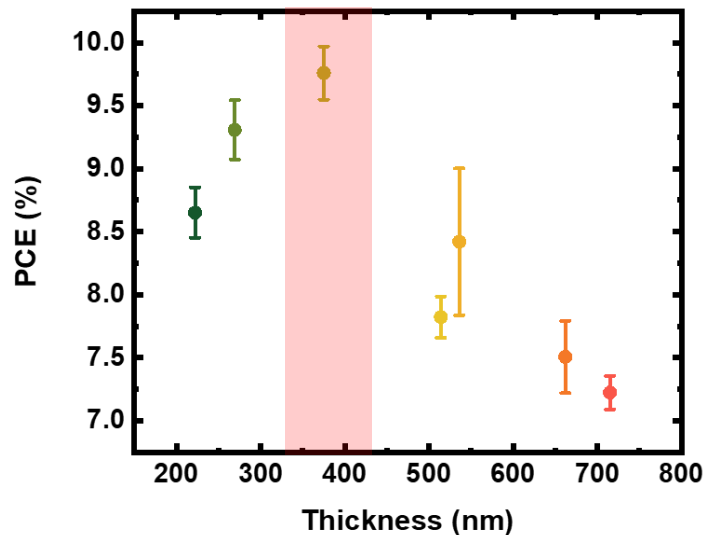
J_{sc} and external quantum efficiency characteristics of a Device with a Jagged Structure for Reflection Suppression

jagged device

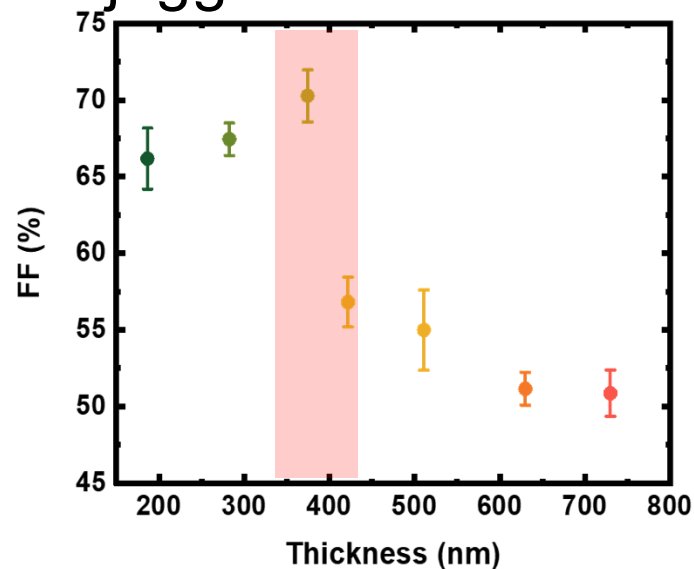
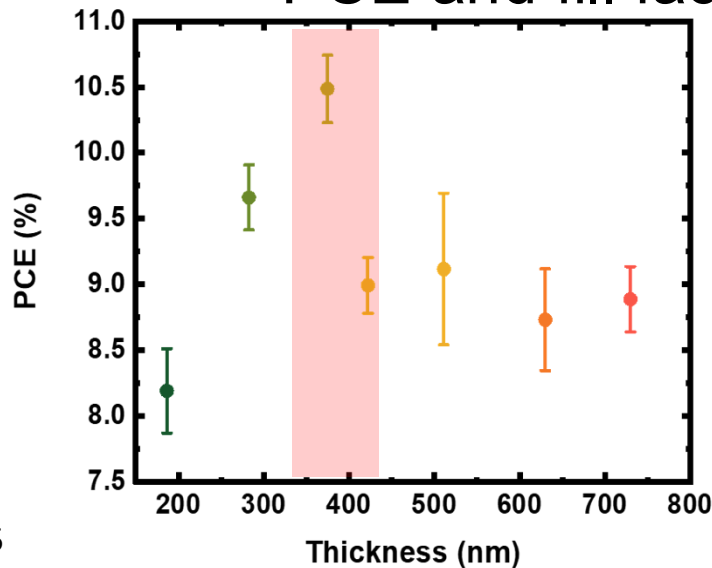


Effects of optical interference on QD solar cells

PCE and fill factor for flat devices

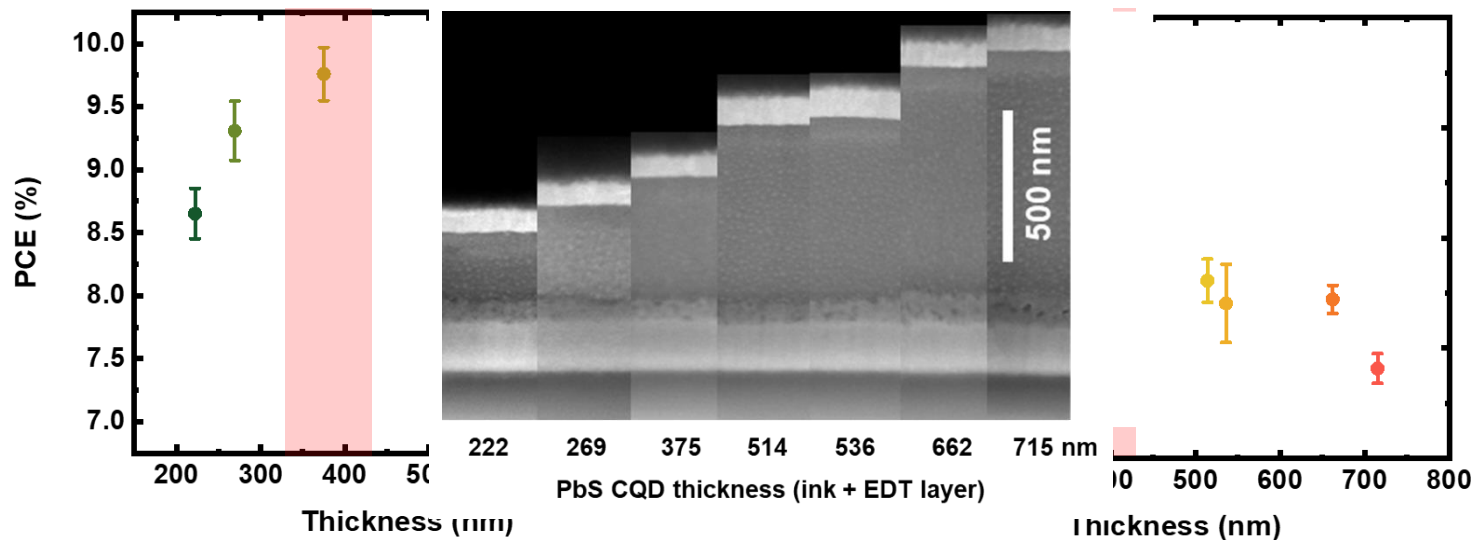


PCE and fill factor for jagged devices



Effects of optical interference on QD solar cells

PCE and fill factor for flat devices



PCE and fill factor for jagged devices

